

Development of Metal Supported SOFC at DLR

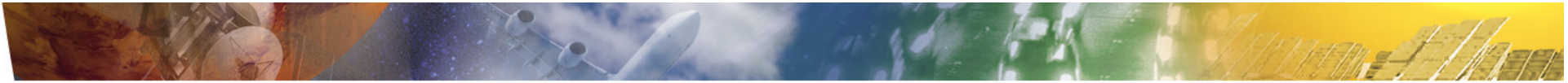
G. Schiller

**German Aerospace Center (DLR)
Institute of Technical Thermodynamics**

**Indo-German Workshop on Fuel Cells and Hydrogen Energy,
Kolkata, January 29-31, 2007**



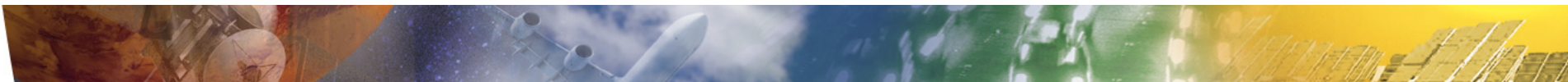
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The DLR
German Aerospace Research Center
Space Agency of the Federal Republic of Germany



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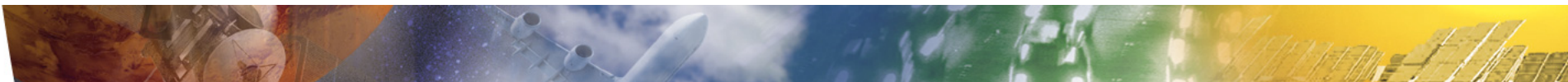
Sites and employees

5.100 employees working
in 27 research institutes and
facilities

- at 8 sites
- in 7 field offices.

Offices in Brussels,
Paris and Washington.

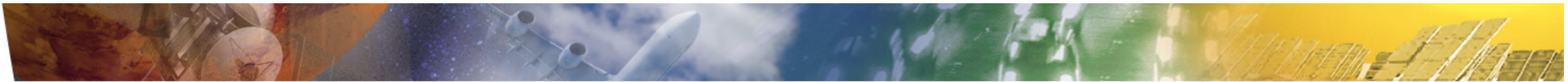




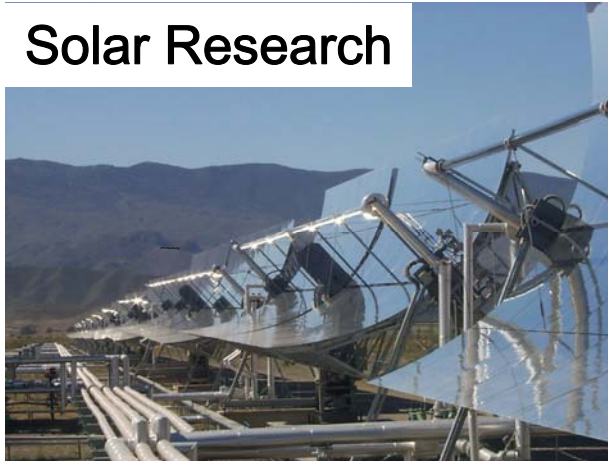
DLR Stuttgart



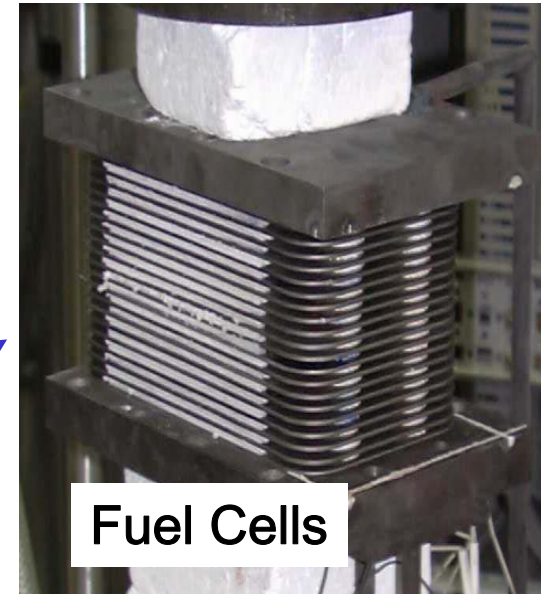
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Solar Research

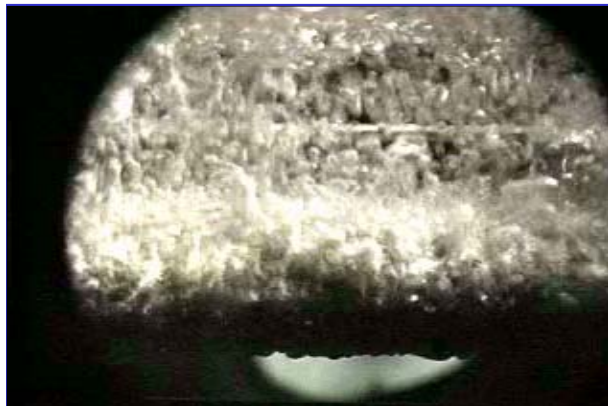


Fuel Cells



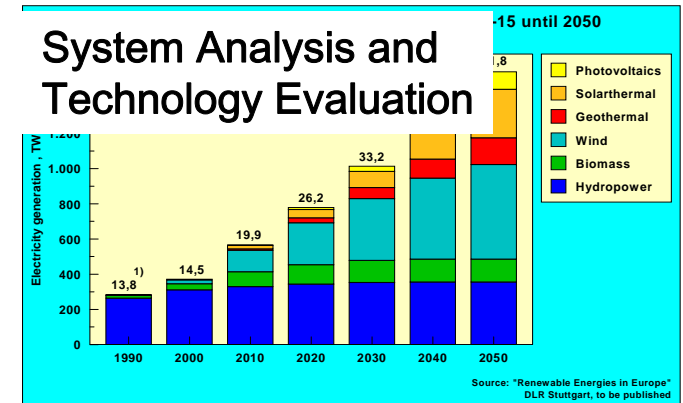
DLR-ITT

145 employees
Stuttgart,
Köln-Porz,
Almeria

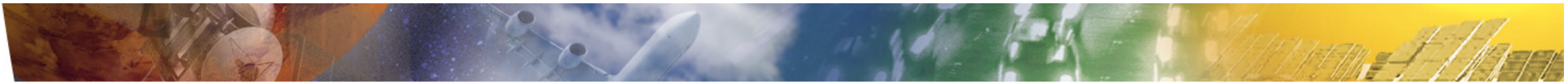


Thermal Process Engineering

System Analysis and Technology Evaluation



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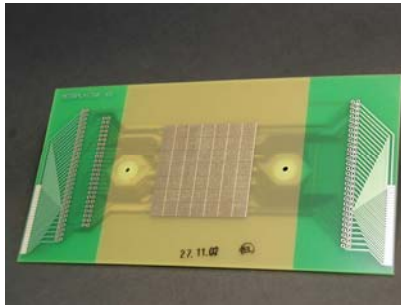


DLR Institute of Technical Thermodynamics

Low Temperature Fuel Cells AFC, PEFC, DMFC



MEA production



Segmented Cells for
analysis and control



PEMA Test
equipment

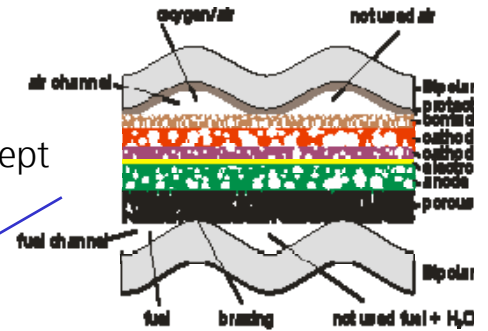
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Fuel Reforming

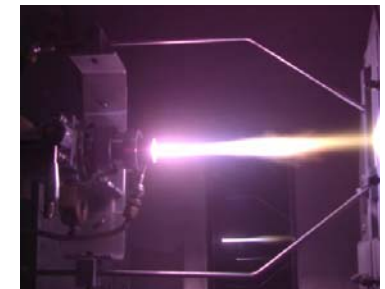
Competence and Activities

System Technology and Analysis

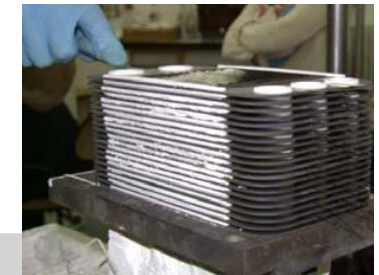
High Temperature Fuel SOFC



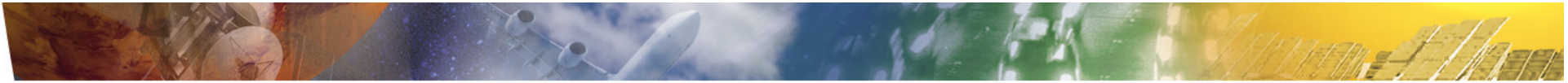
Spray Concept



Plasma deposition
process

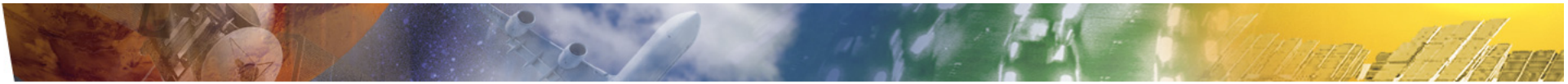


SOFCs for APUs

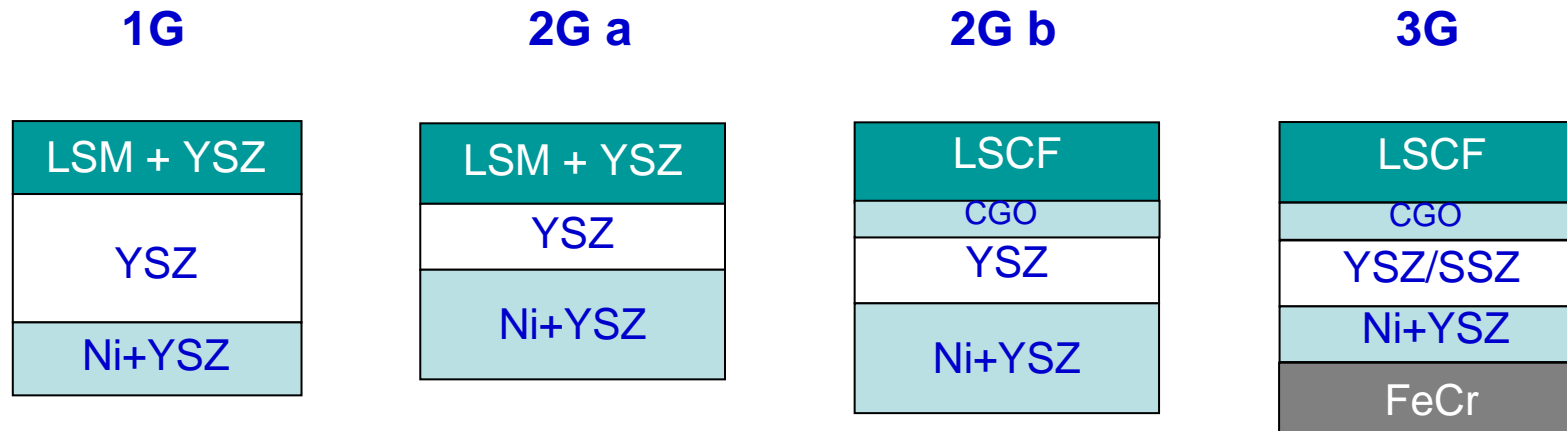


Outline

1. Introduction
2. SOFC Spray Concept of DLR
3. Plasma Deposition Technologies
4. Development of Cells and Functional Layers
5. Metallic Substrate Support
6. Electrochemical Performance of Cells and Stacks
7. Spatially-Resolved Cell Characterisation
8. Conclusion



SOFC Development from 1st (1G) to 3rd Generation (3G)

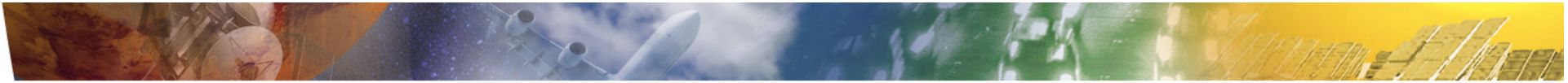


Improved power density

Improved long-term stability

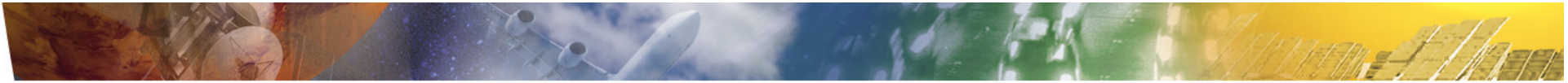
Reduced operating temperature





Advantages of Metal Supported Cells (MSC)

- High electrical conductivity of the metal support
- High thermal conductivity of the metal support
- High stability of the cell during temperature changes
- High and homogeneous mechanical stability of the cell
- Application of conventional joining and sealing techniques
- Cost reduction for materials and fabrication technologies



Requirements for Metal Substrate Supports

- High electrical conductivity
- Adapted thermal expansion coefficient ($10-12 \cdot 10^{-6} \text{ K}^{-1}$)
- High corrosion stability in oxidising und reducing, moist atmosphere
- Sufficient mechanical stability
- High gas permeability (porosity > 40 Vol. %)
- Flat surface area for plasma sprayed functional layers

SOFC Spray Concept of DLR

Plasma Deposition Technology

Thin-Film Cells

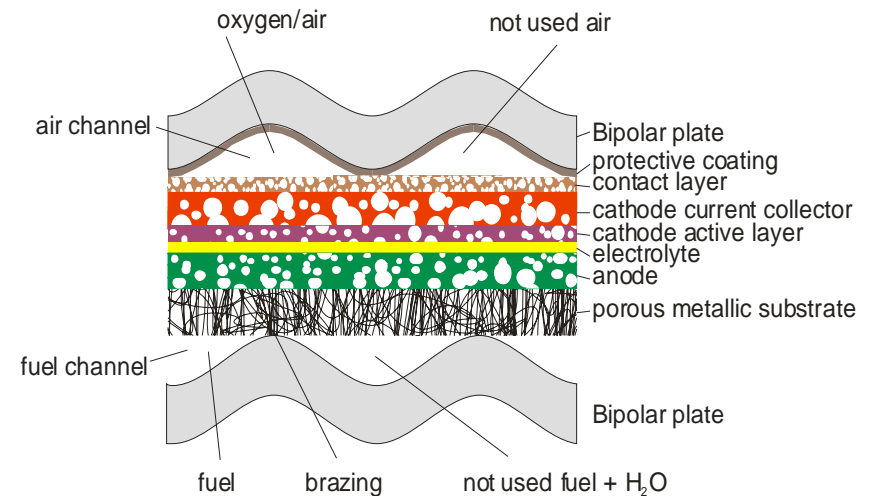
Ferritic Substrates and Interconnects

Compact Design with Thin Metal Sheet Substrates

Brazing, Welding and Glass Seal as Joining and Sealing Technology

Objective of DLR Development:

Light-weight stack of 5 kW power with high performance, rapid heat-up and good thermal cycling properties

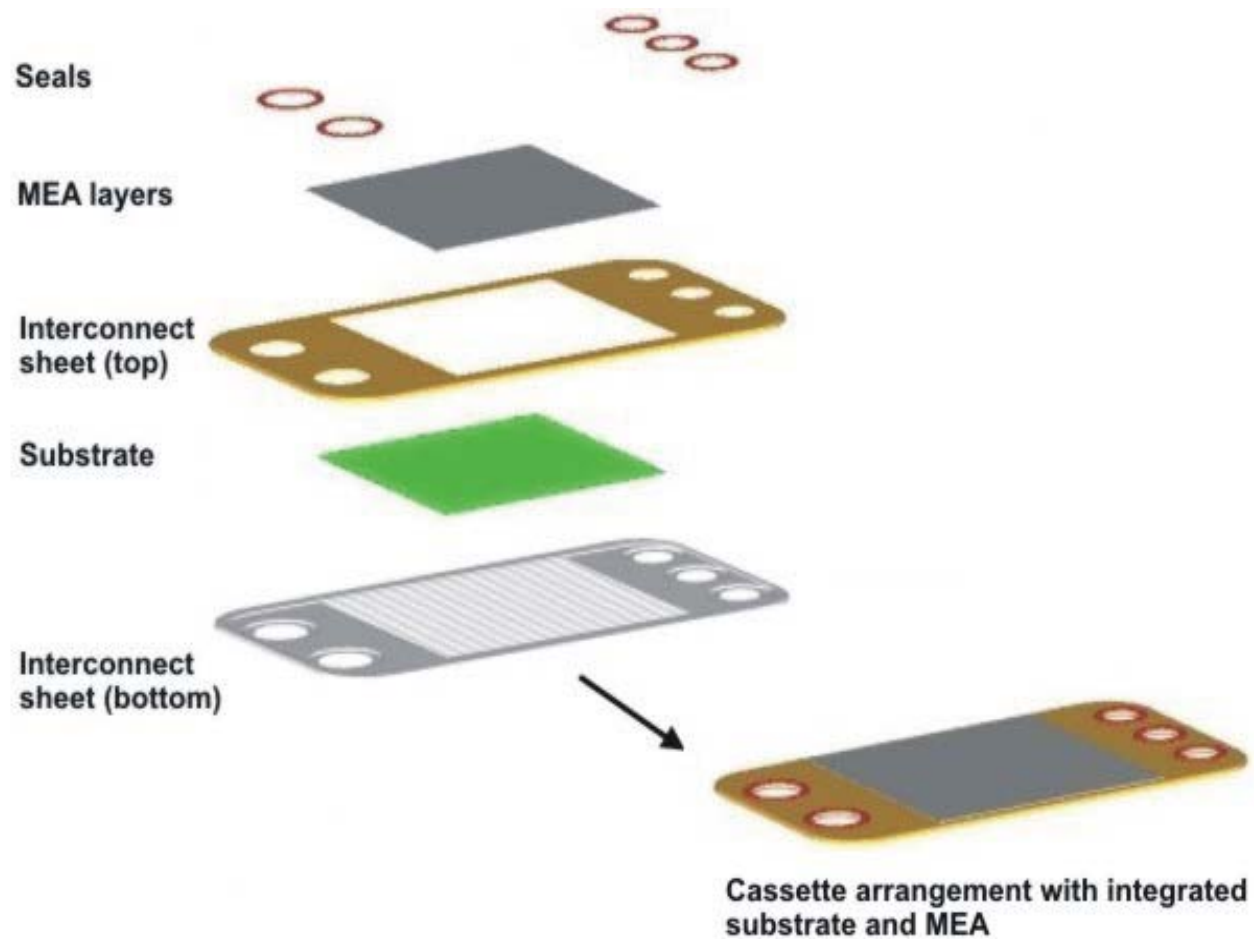


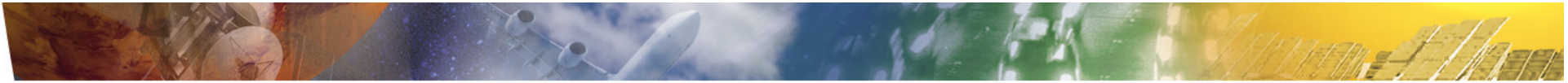
Schematic of DLR-SOFC Design with Metallic Substrate



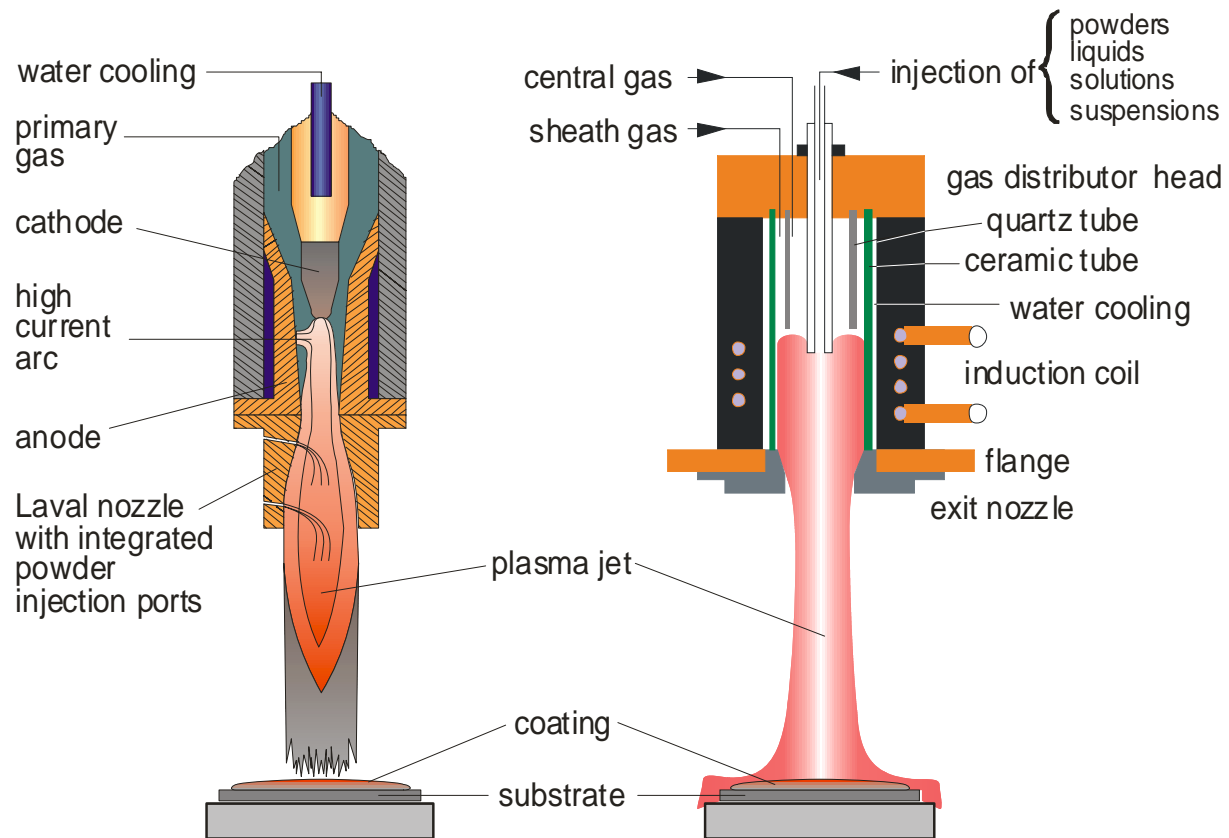
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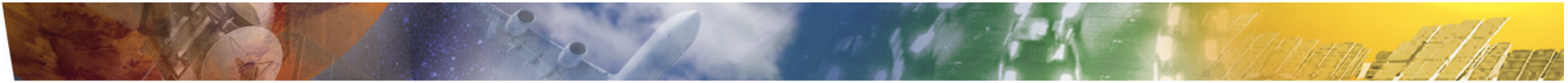
Cell Design for APU Application



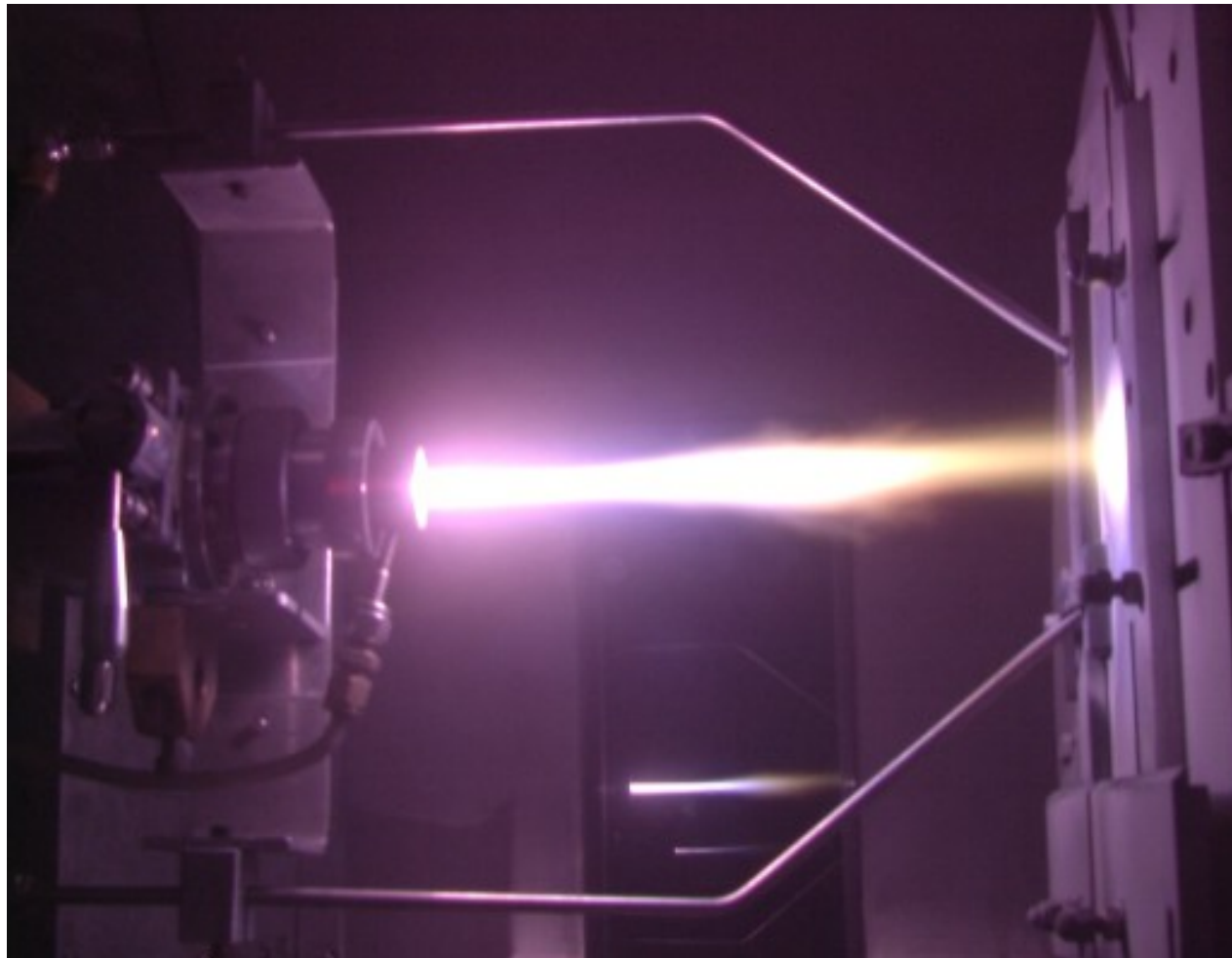


Principles of DC and RF Plasma Spraying

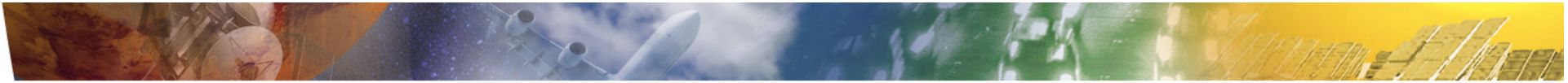




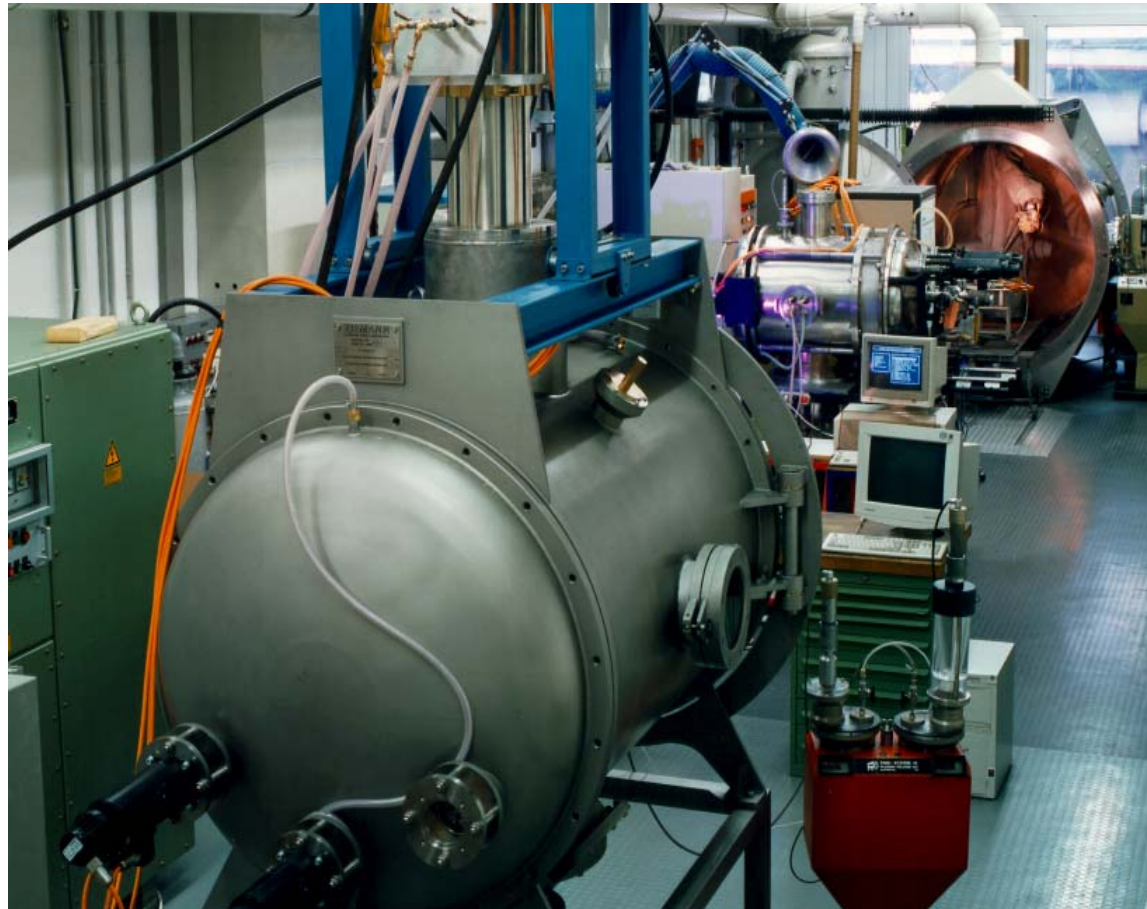
Vacuum Plasma Spraying of SOFC Cells



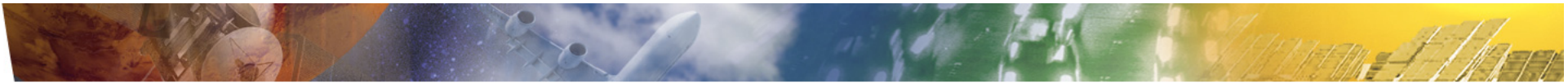
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Plasma Spray Laboratory at DLR Stuttgart



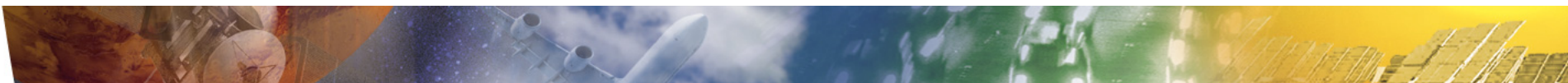
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VPS Pilot Facility at DLR Stuttgart

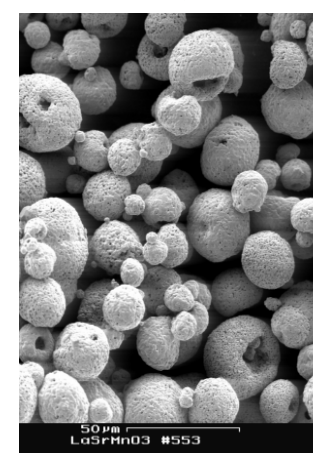
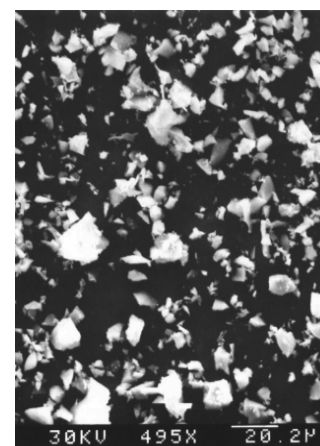
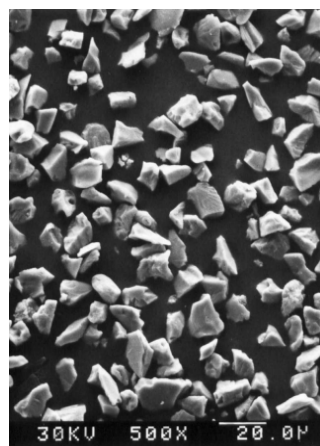
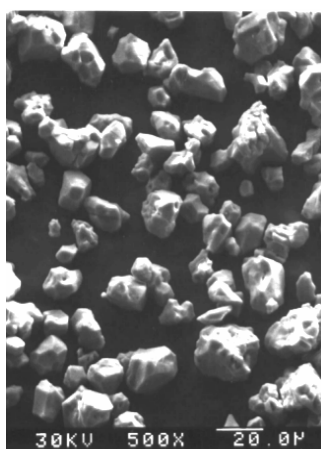


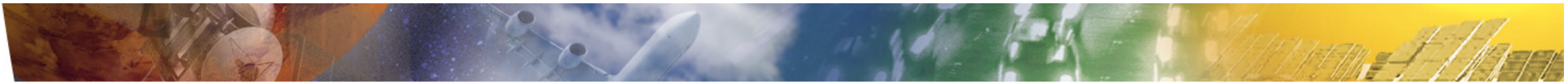
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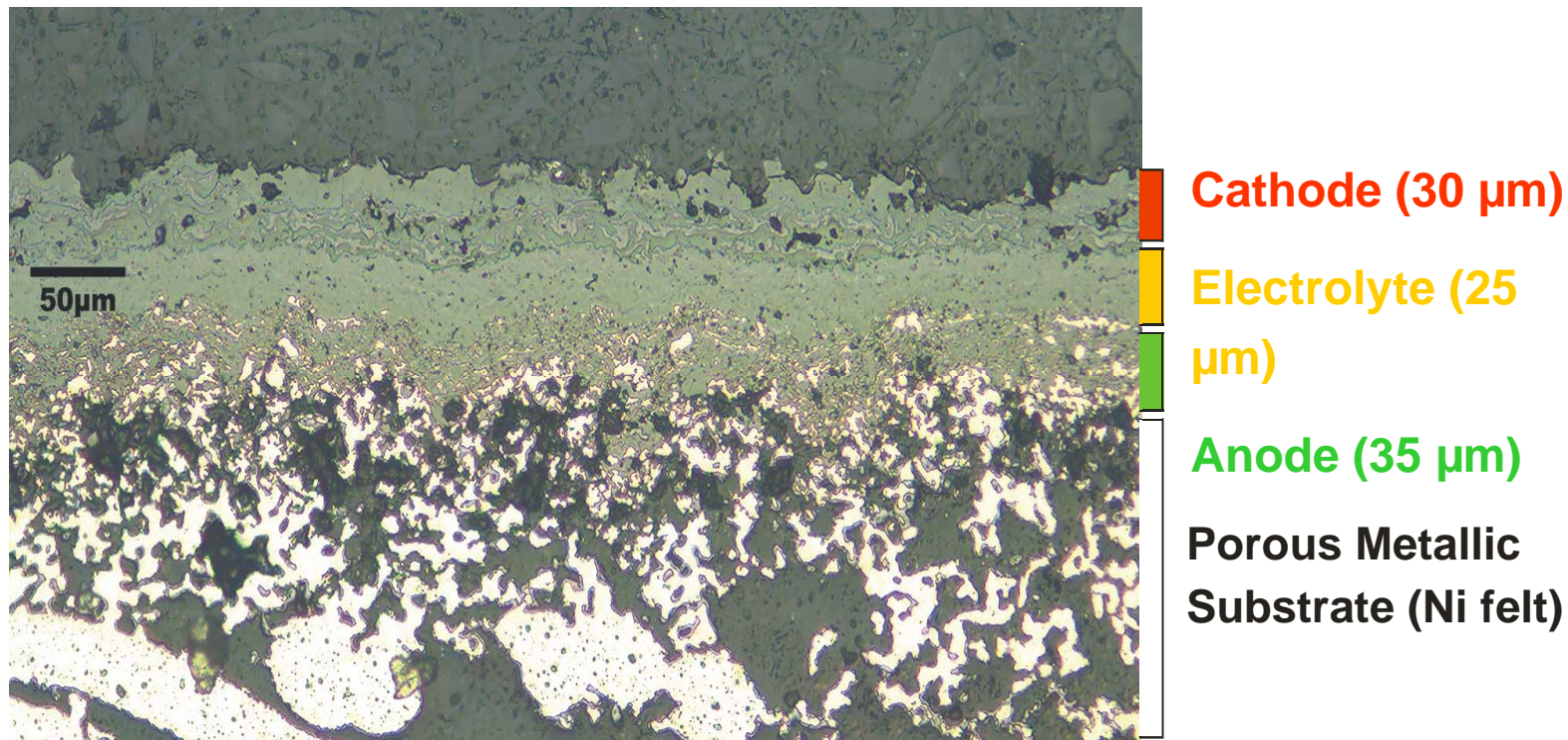
Powders Used for the Spraying of the Cells

Powder	NiO	ZrO ₂ - 7 mol %Y ₂ O ₃	ZrO ₂ - 10 mol%Sc ₂ O ₃	(La _{0.8} Sr _{0.2}) _{0.98} MnO ₃
Short name	NiO	YSZ	ScSZ	LSM
Morphology	sintered, crushed	sintered, crushed	sintered, crushed	sintered, spherical
Size distribution	10-25 µm	5-25 µm	2-35 µm	20-40 µm
Supplier	Cerac, USA	Medicoat, Switzerland	Kerafol, Germany	EMPA, Switzerland

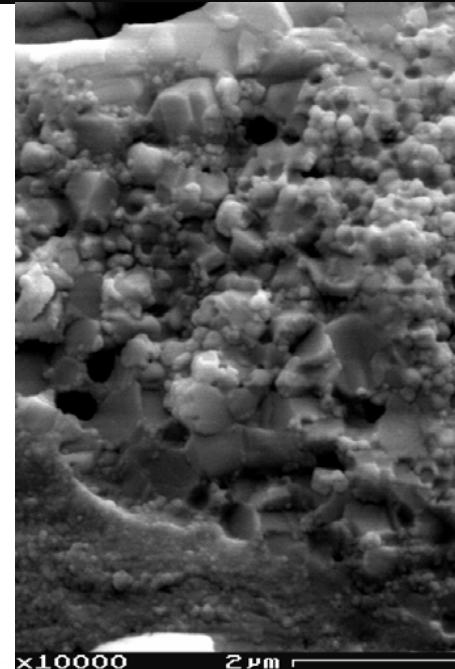
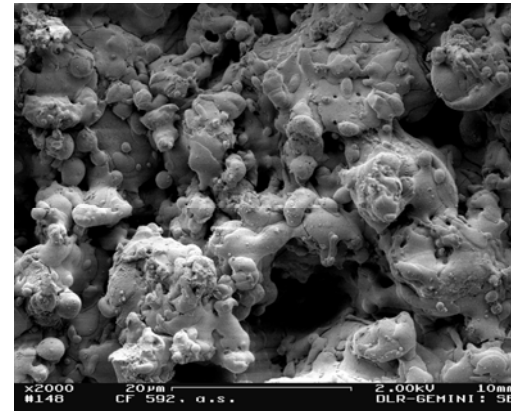
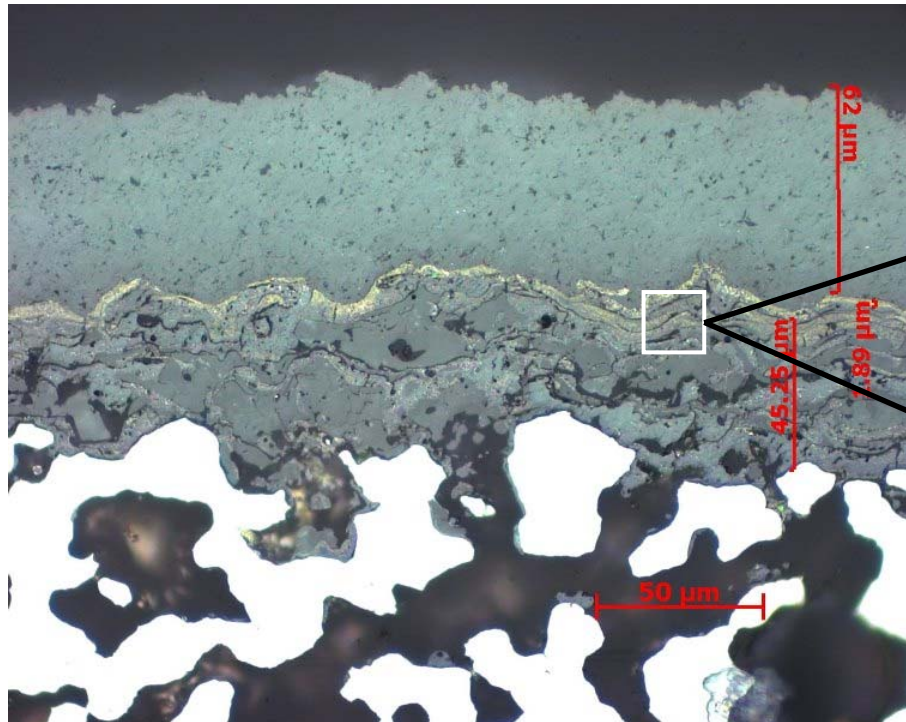




Cross Section of Entirely Vacuum Plasma Sprayed Thin-Film MEA on a Porous Ni Felt



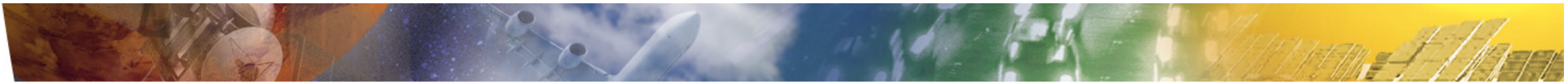
Development of Nanostructured Anode Layer



Permeability coefficient (10^{-15} m^2)

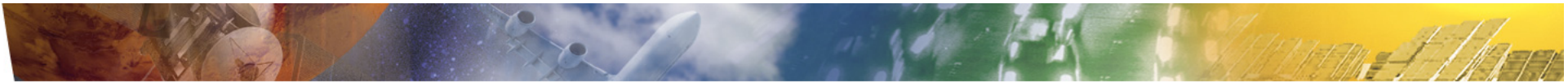
VPS ref	APS conv.	Ni-C	Double Layer
2	12	30	54





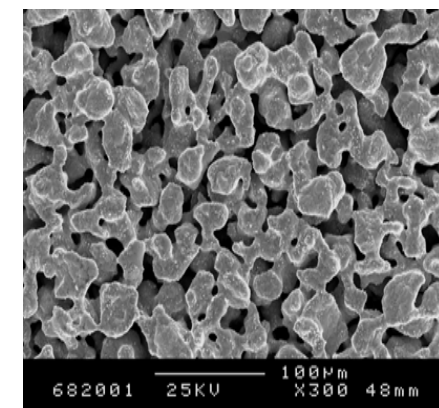
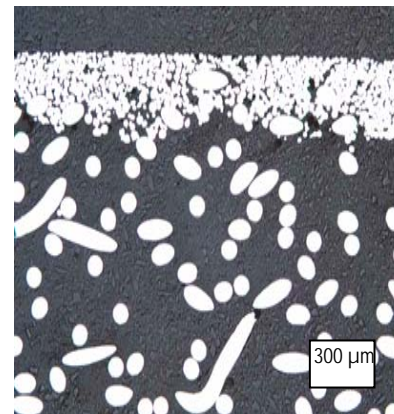
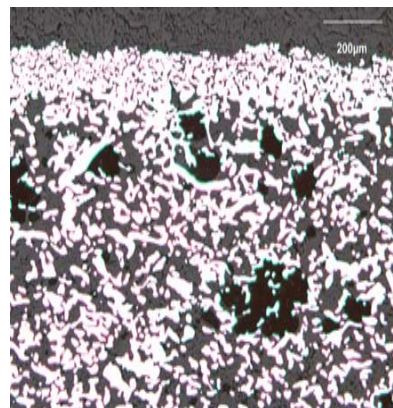
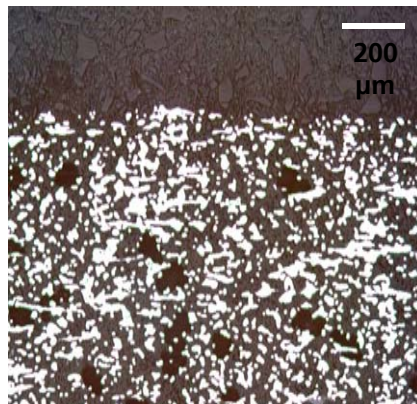
Ferritic Alloys Studied for Porous Metallic Substrates

Alloy	Supplier	Composition
Ferrochrom (1.4742)	ThyssenKrupp	18% Cr, 0.9% Al, 0.9% Si, 0.69% Mn, 0.06% C
CrAl20 5 (1.4767)	ThyssenKrupp	19% Cr, 5.5% Al, 0.5% Si, 0.5% Mn, 0.05% C
FeCrAlY	Technetics	22% Cr, 5% Al, 0.1% Y
ZMG 232	Hitachi Metals	21% Cr, 0.08% Al, 0.43% Si, 0.47% Mn, 0.02% C
SUS 430 HA	Nippon Steel	16% Cr, 0.13% Al, 0.29% Si, 0.13% Mn, 0.05% C
SUS 430 Na	Nippon Steel	16% Cr, 0.01% Al, 0.29% Si, 0.56% Mn, 0.05% C
CroFer22 APU	ThyssenKrupp	22% Cr, 0.12% Al, 0.1% Si, 0.41% Mn, 0.16% Ni, 0.05% Ti, 0.08% La
IT 14	Plansee	26% Cr, < 0.03% Al, < 0.03% Si, Mo, Ti, Mn, Y ₂ O ₃



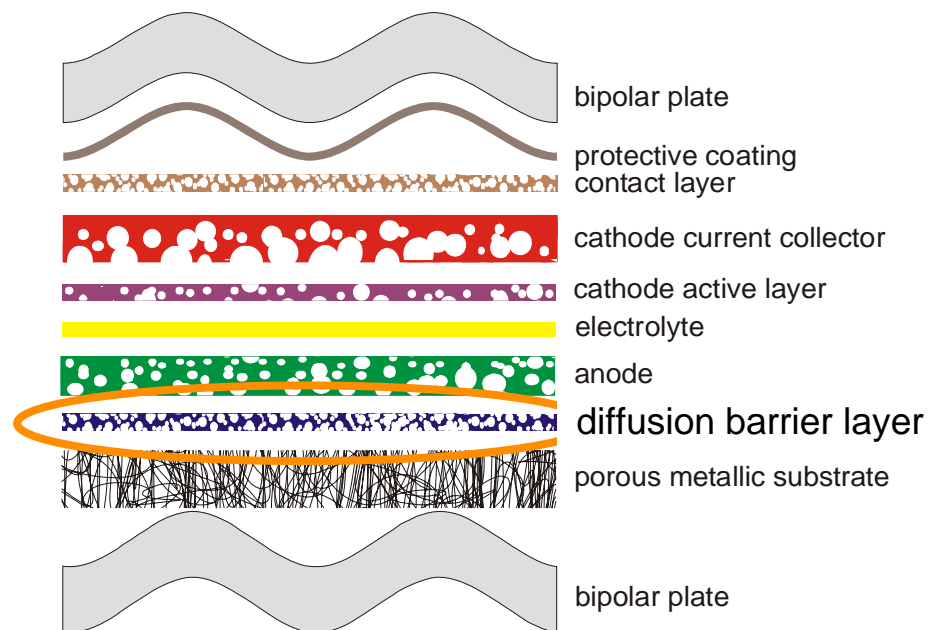
Porous Metallic Substrates Used for the Plasma Spray SOFC Concept

Substrate	Felt	Foam	Knit fabric	Sintered plate
Material	Ni	Fe-22Cr-5Al-0,1Y	Fe-22Cr-0,5Mn	Fe-26Cr (Y_2O_3)
Thickness	~ 1,0	~ 1,8	~ 1,0	~ 1,0
Porosity	~ 85	~ 80	~ 90	~ 50
Supplier	Bekaert, Belgium	Technetics, USA	Rhodium, Germany	Plansee AG, Austria





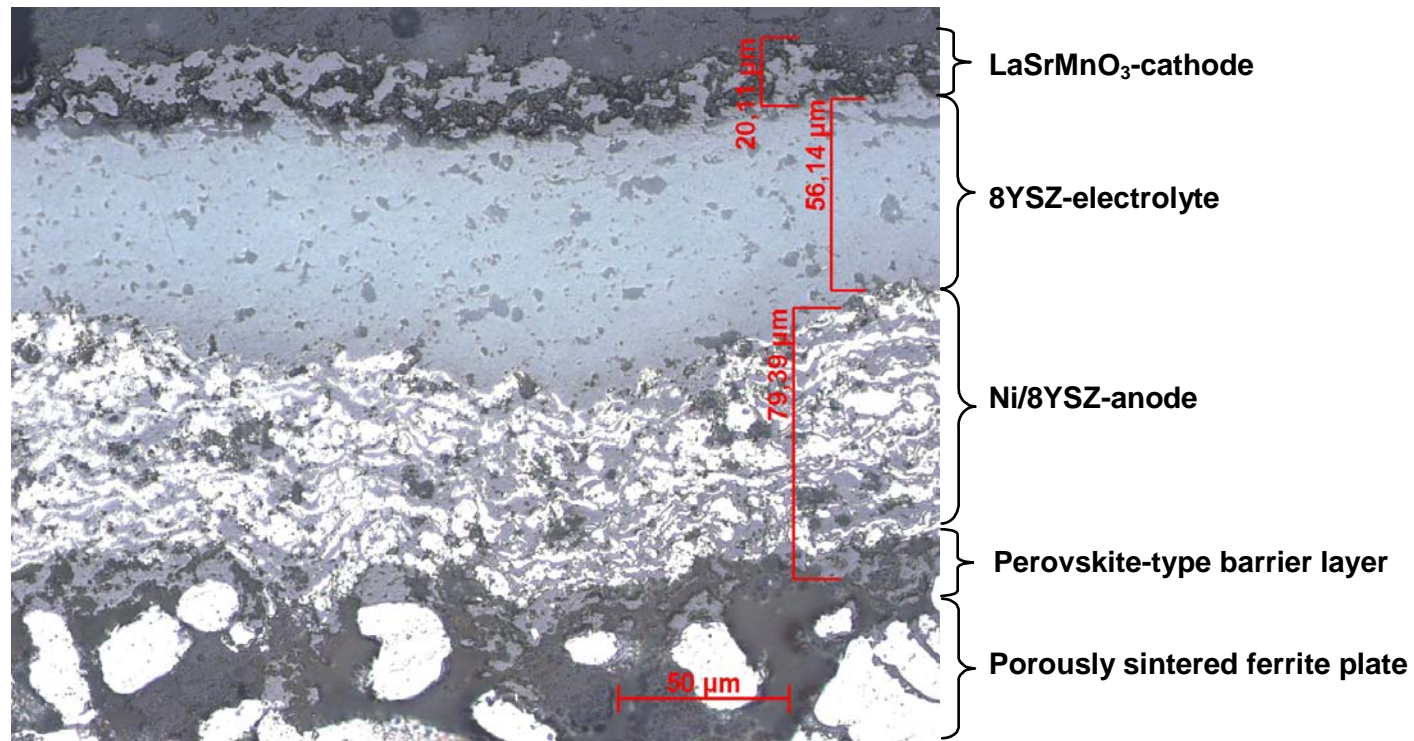
Experimental Approach For a Diffusion Barrier Layer at the Anode Side

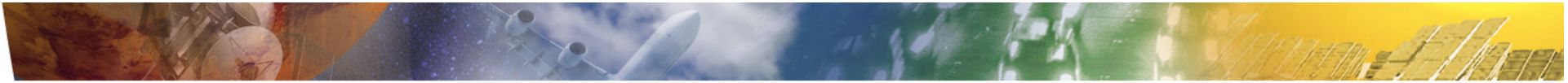


Requirements

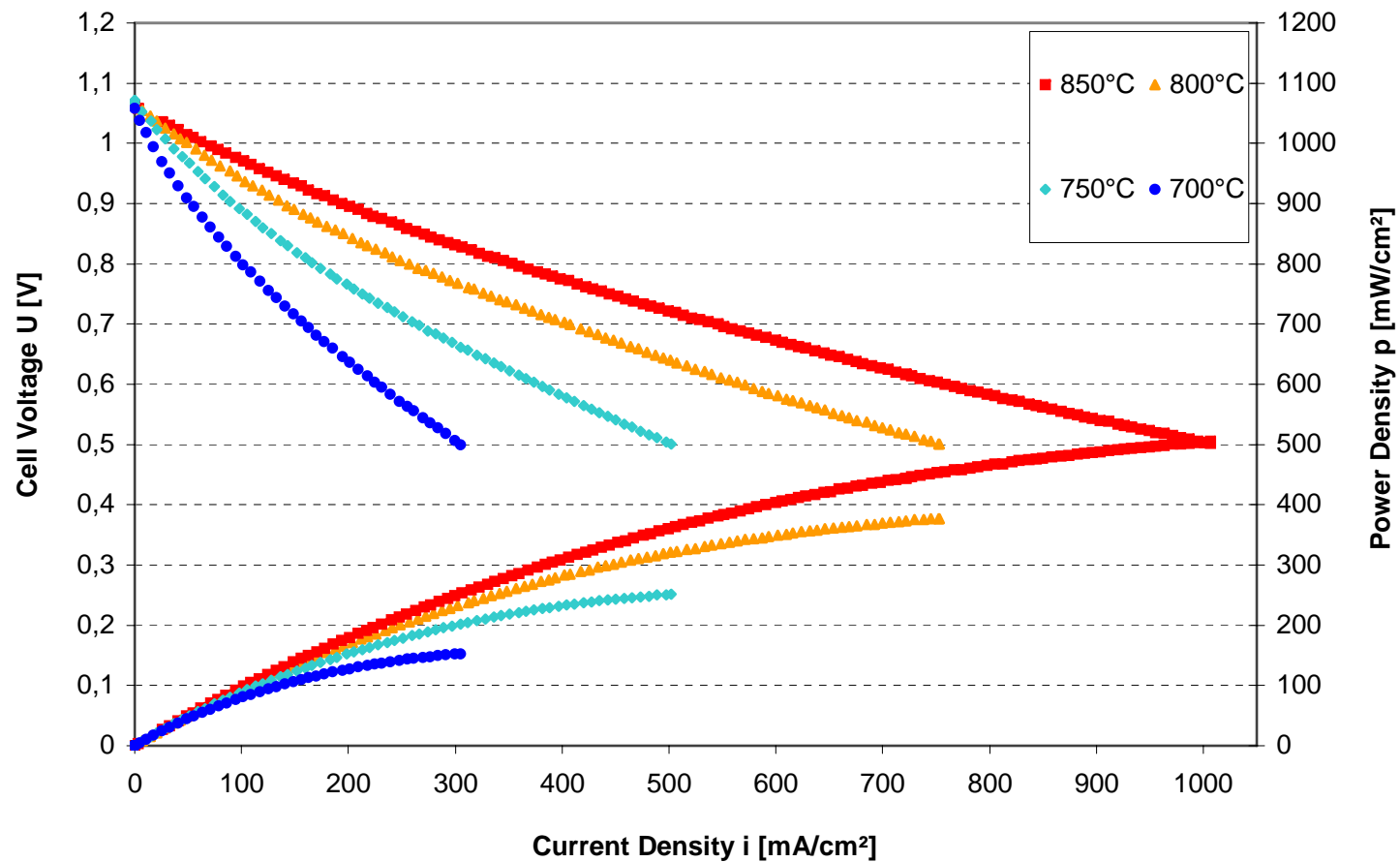
- Porous structure
- Adapted thermal expansion coefficient ($\alpha_{\text{tech.}} = 10^{-11} \text{ x } 10^{-6} \text{ K}^{-1}$)
- High electronic conductivity in reducing anode atmosphere [$\sigma = 1\text{-}3 \text{ S/cm}$, $p(\text{O}_2) = 10^{-16} \text{ bar}$]
- Chemical stability in reducing humid anode gas atmosphere
- Barrier effect for Fe, Cr und Ni species
- Elektrochemical compatibility at cell operation (chemical inert behavior)

Plasma Sprayed Diffusion Barrier Interlayer

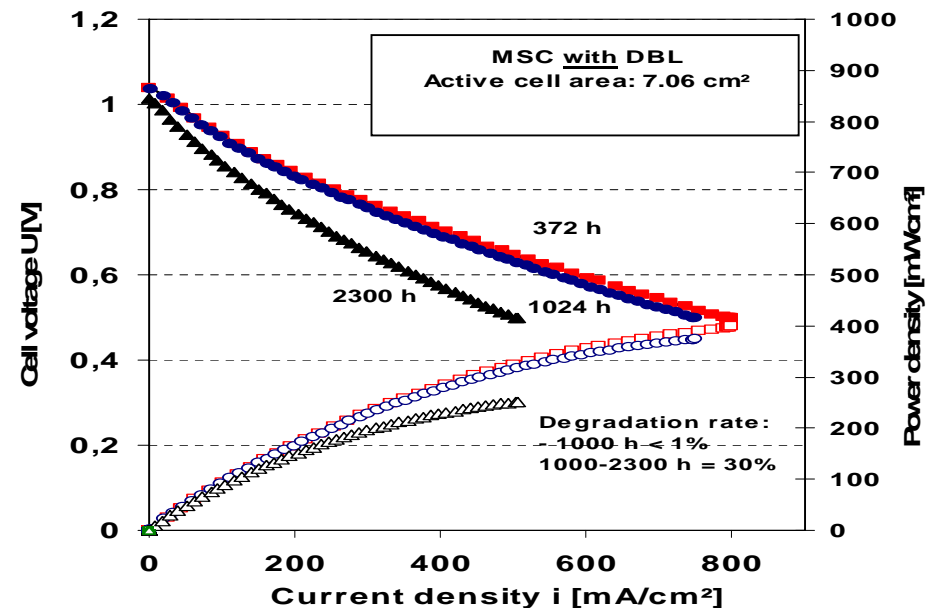
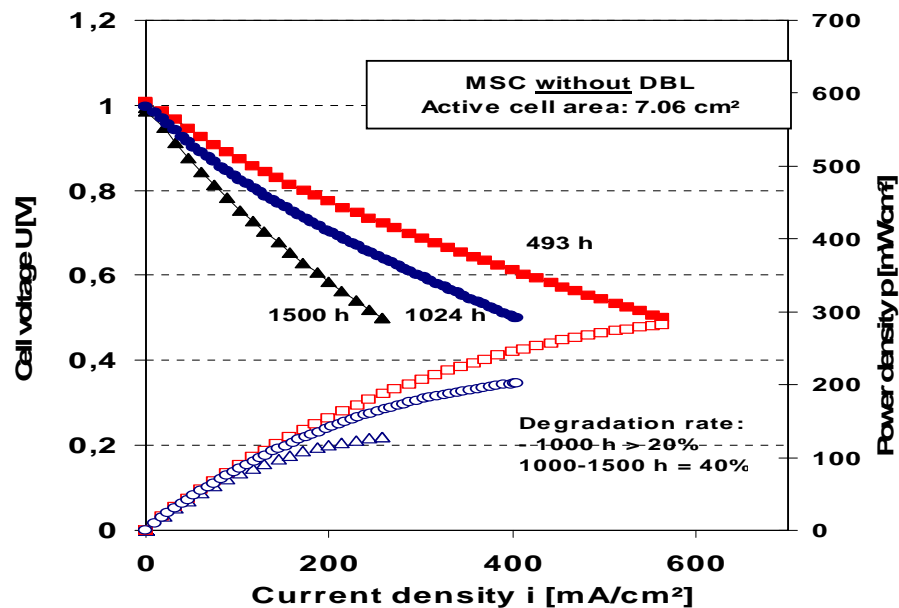




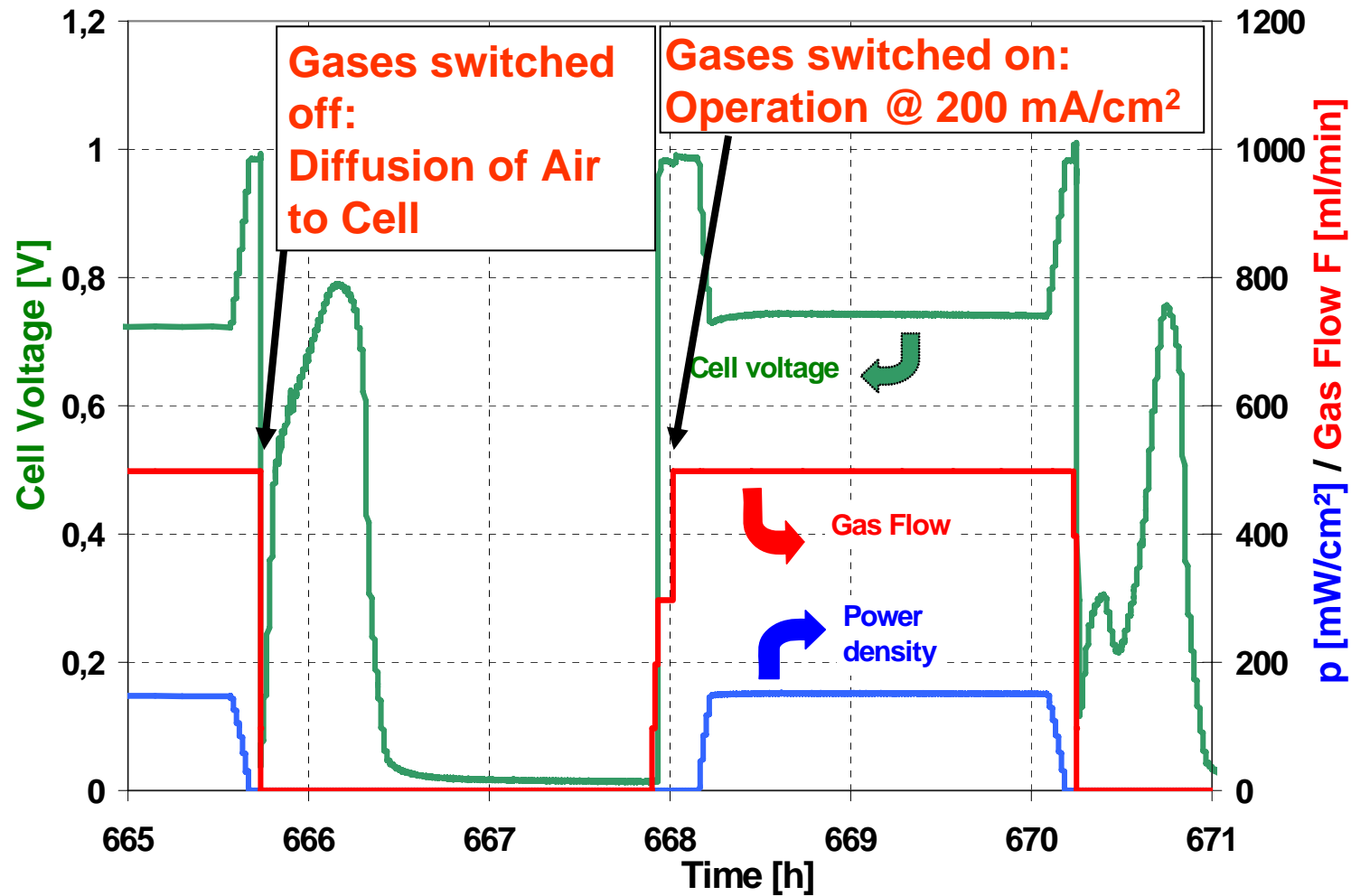
I-V Characteristics of a VPS Cell with Improved Anode and Cathode Layers (LSM) as a Function of Different Operating Temperatures (0.5 H₂+0.5 N₂ / 2 Air)



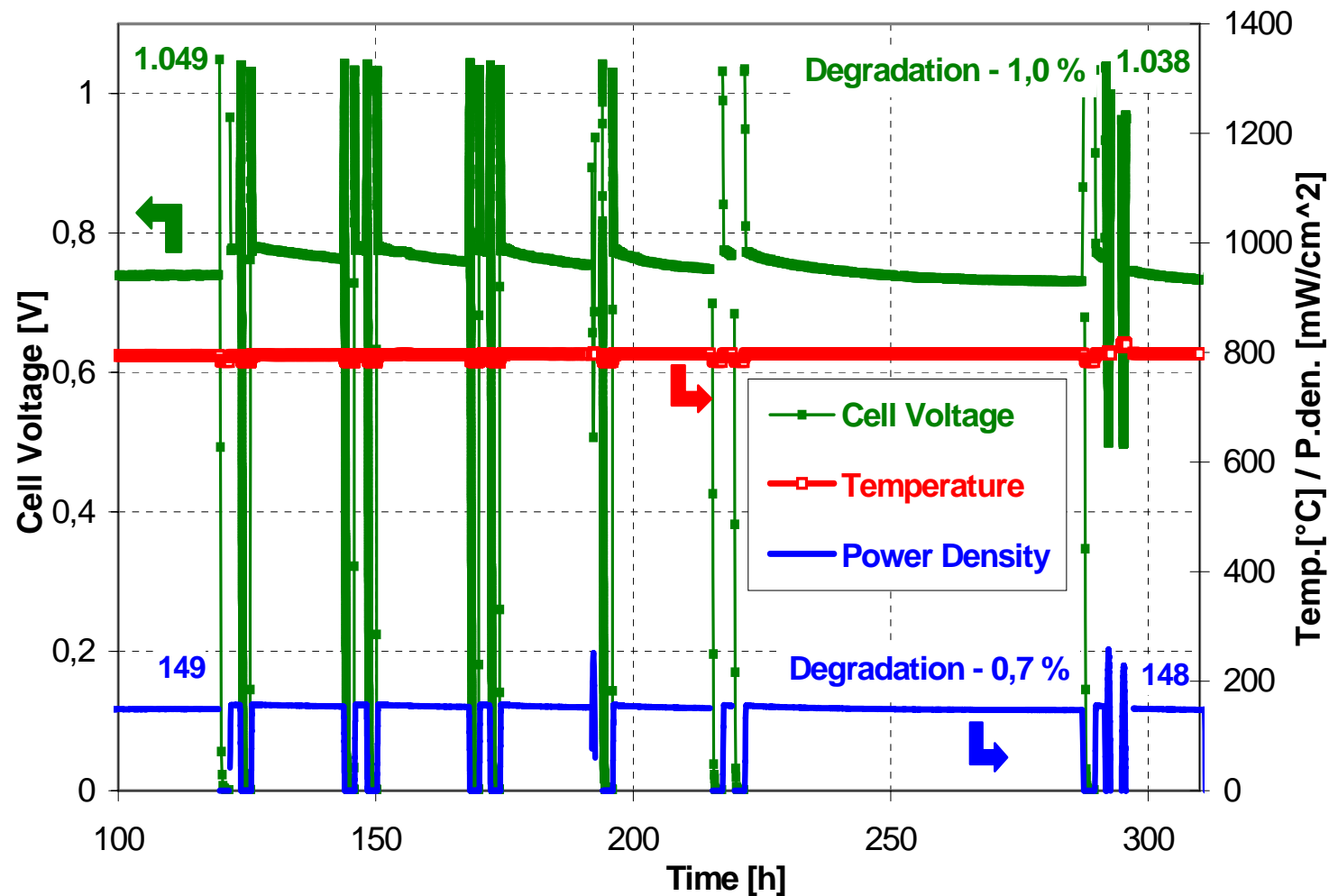
Electrochemical Performance of VPS Cells With and Without Diffusion Barrier Layer in Operation with Simulated Reformate H₂/N₂ and Air



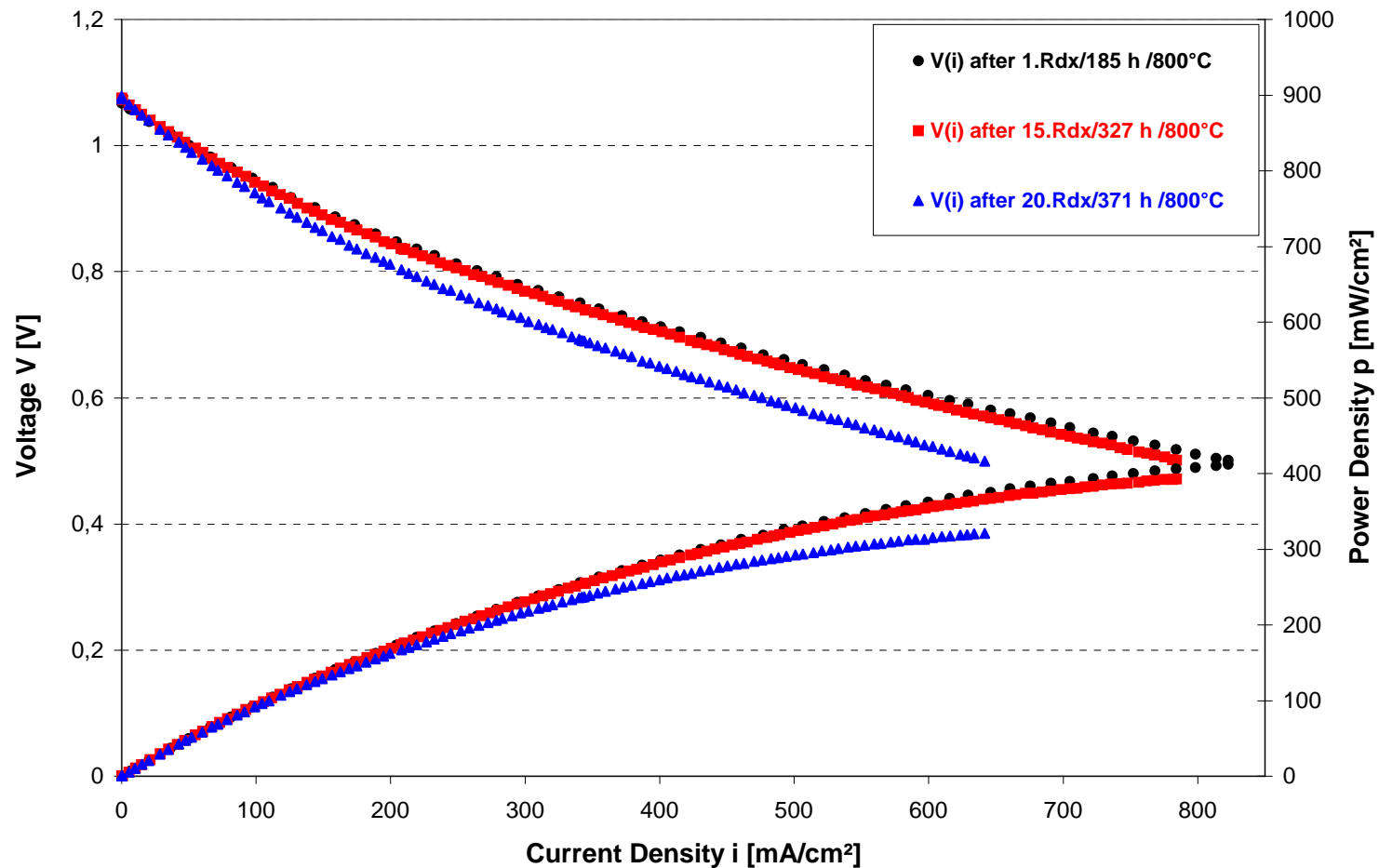
Redox Cycling Conditions



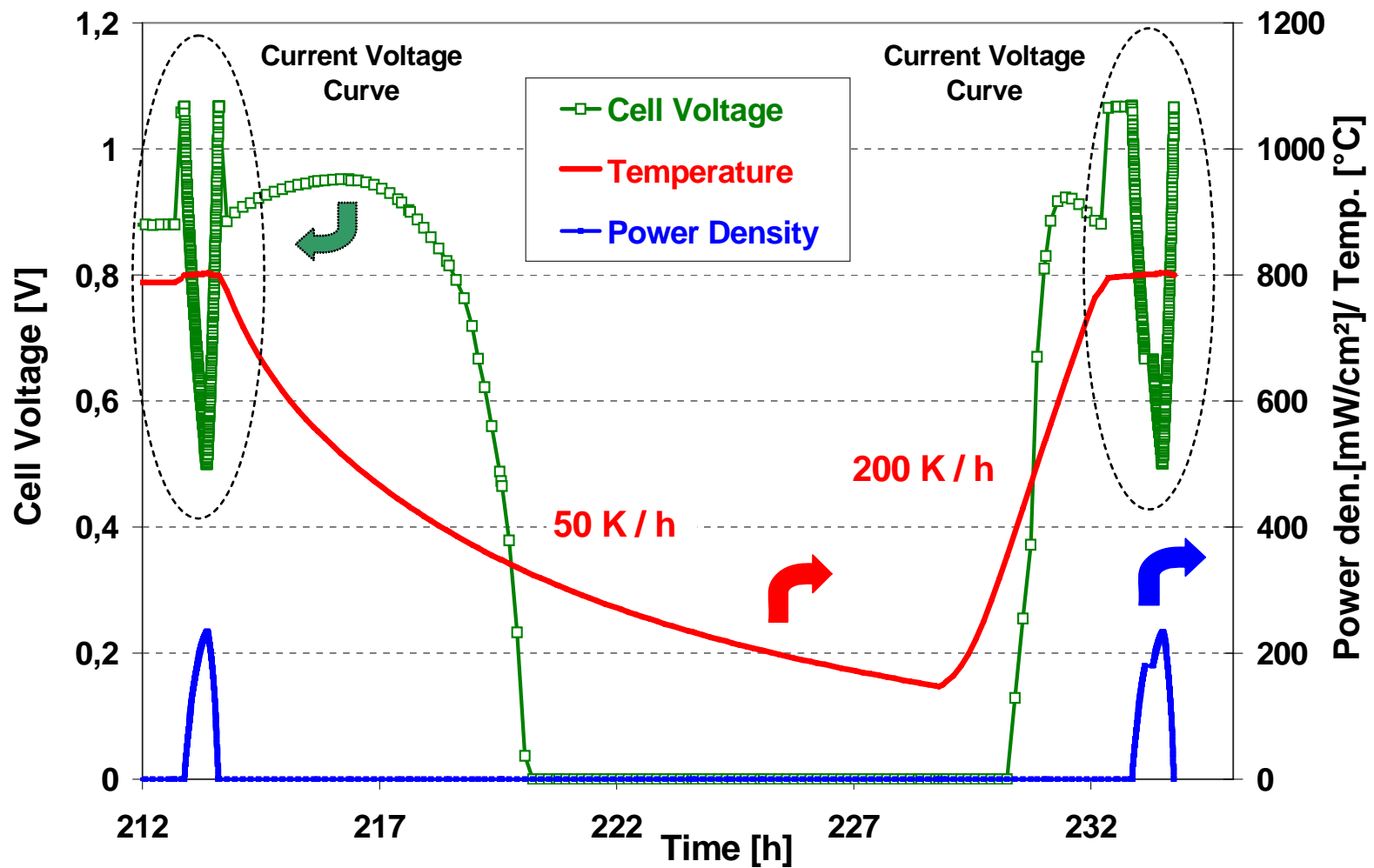
Electrochemical Behaviour of a SOFC (12cm²) during 10 Redox Cycles (800°C, 0.5N₂+0.5H₂ / 2.0 Air, 200 mA/cm²)



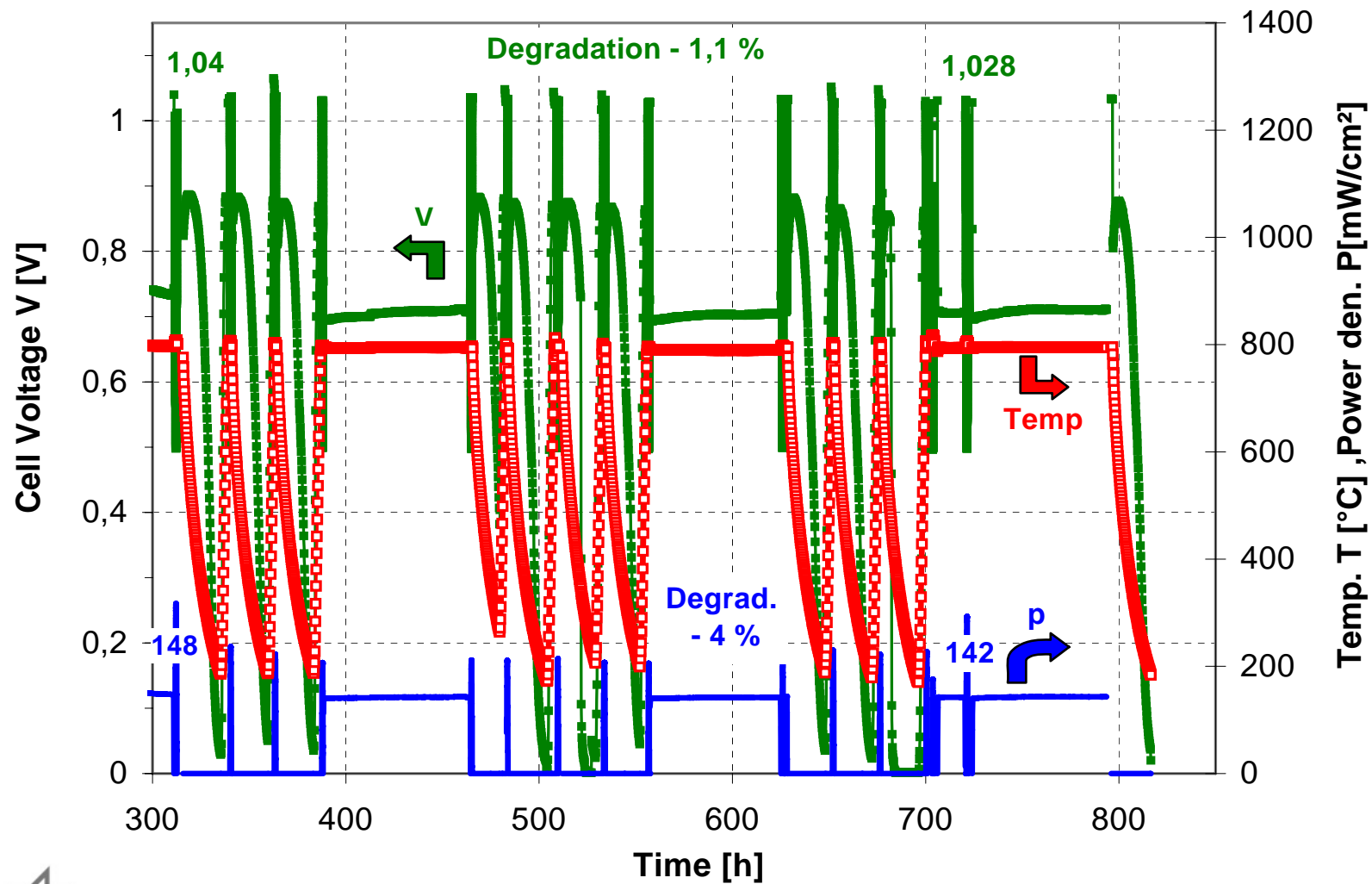
I-V Characteristics of a VPS Cell with Improved Anode and Electrolyte Layers / LSM Cathode after Redox Cycling

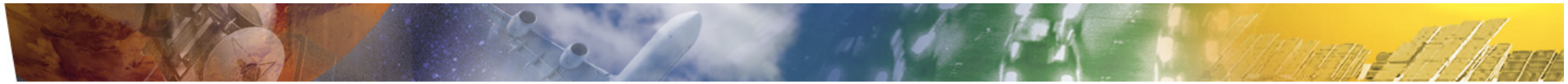


Thermal Cycling Conditions

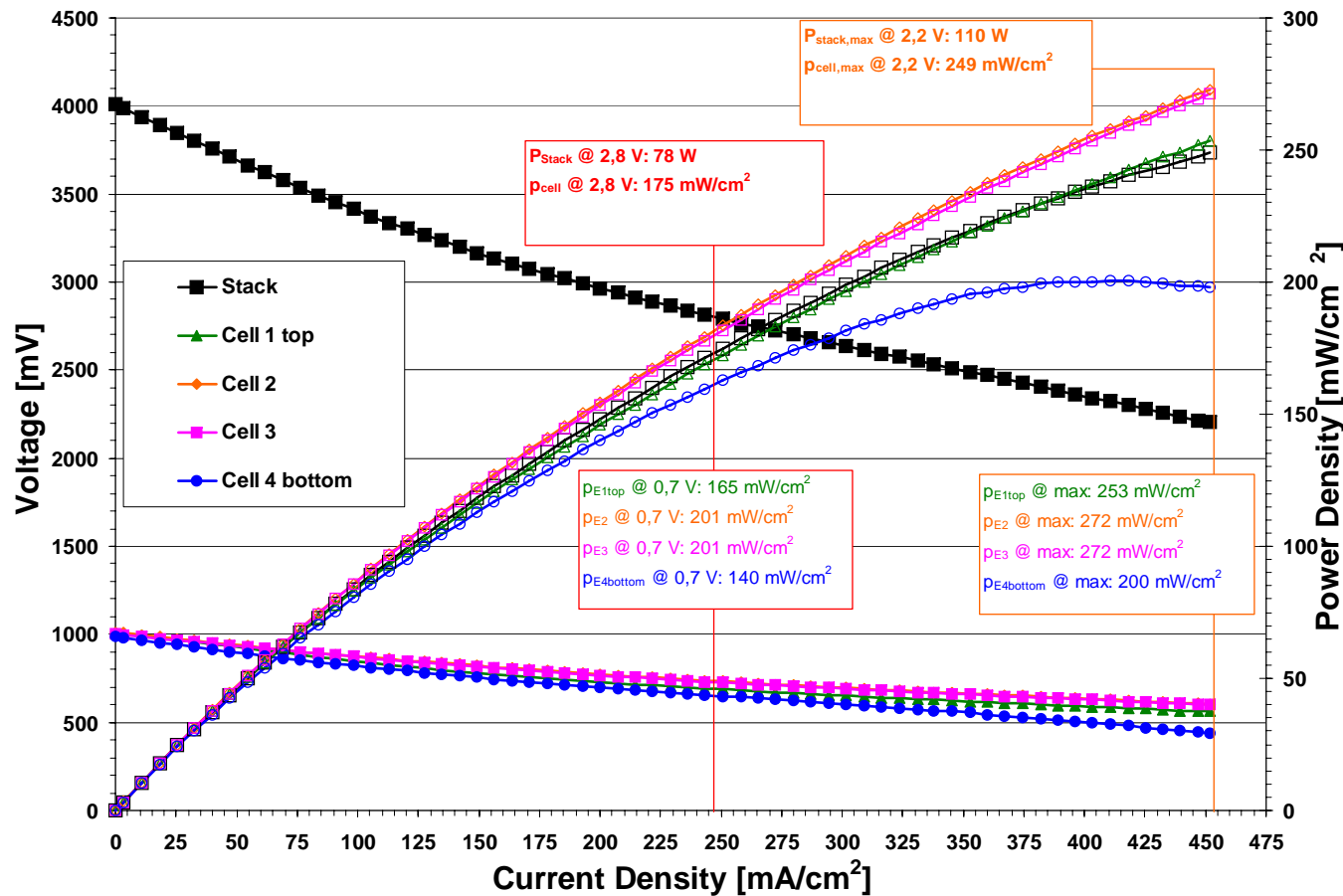


Electrochemical Behaviour of a SOFC (12 cm²) during 10 Thermo Cycles (800°C, 0.5N₂+0.5H₂ / 2.0 Air, 200 mA/cm²)



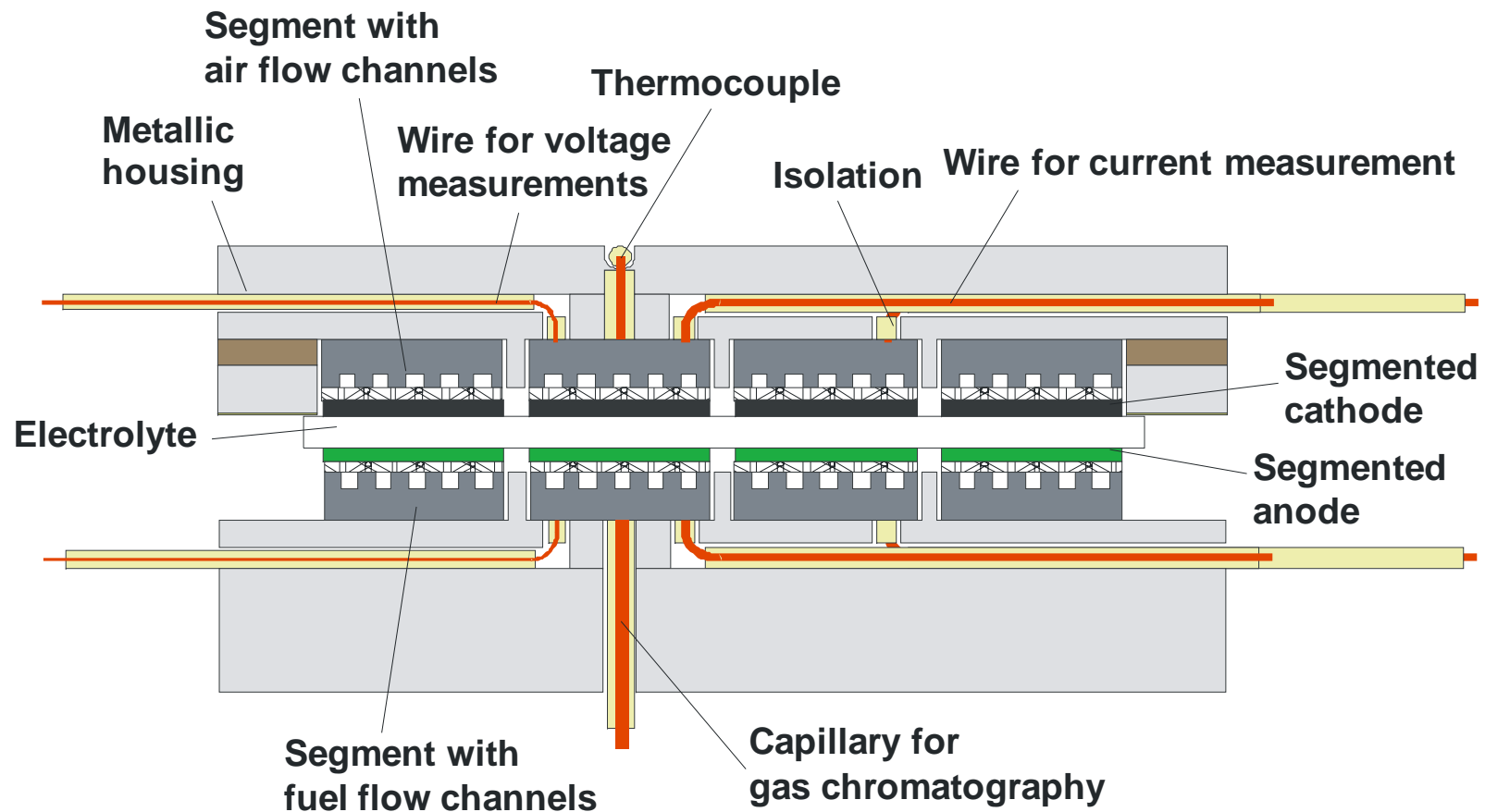


I-V Characteristics of a 4-Cell Stack in Cassette Configuration Operated at 800 °C with H₂/N₂-Air (12.5/12.5/80 smlpm/cm²)

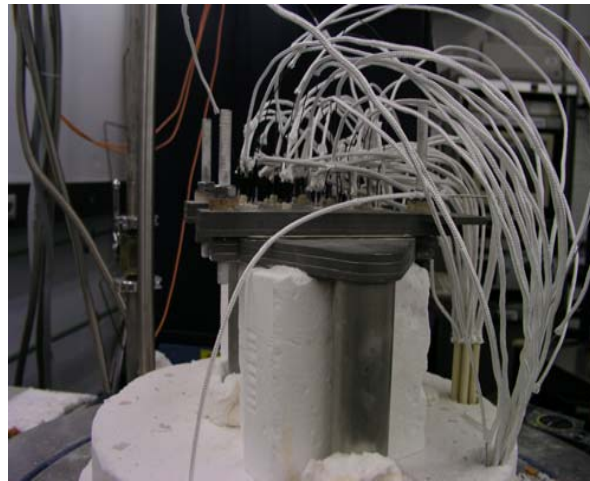


The segmented approach of DLR

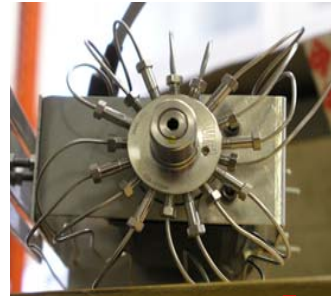
Schematic of the metallic housing



Cell Design and Test Rig

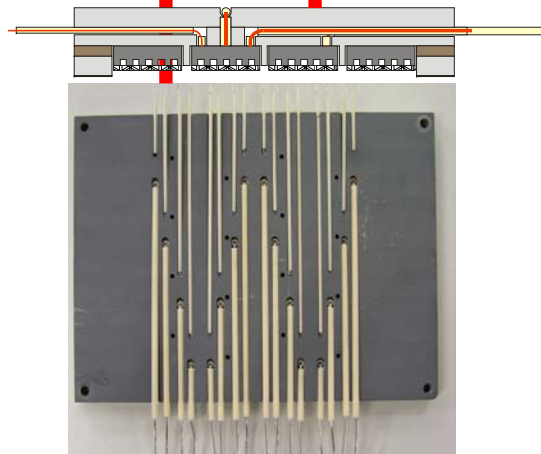


„Simple“ measuring device
for cassettes

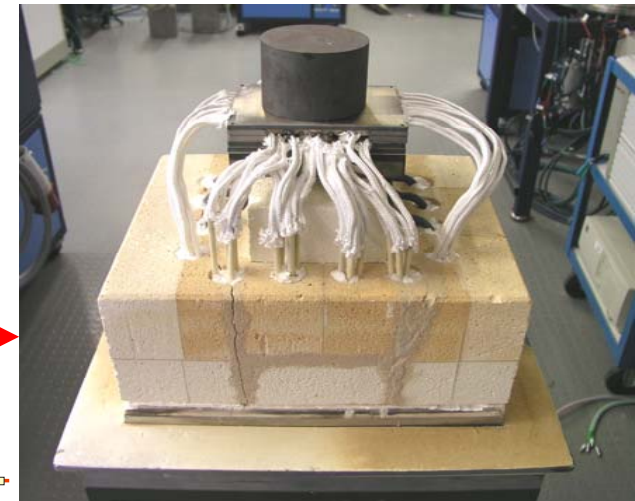


GC measurement

Sealing and contacting



More flexible housing, less
disturbed impedance signals



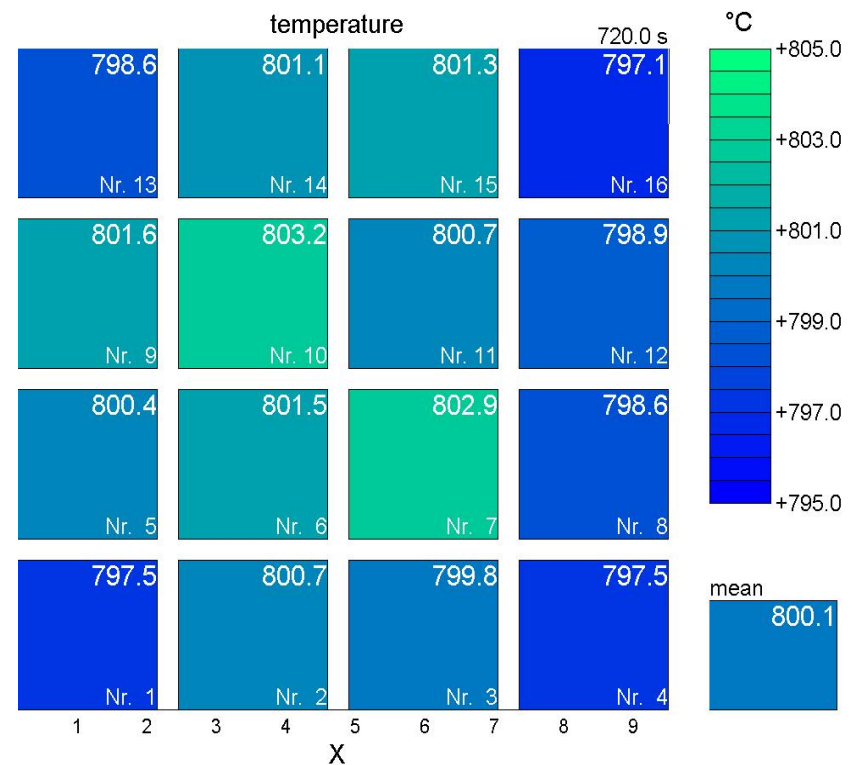
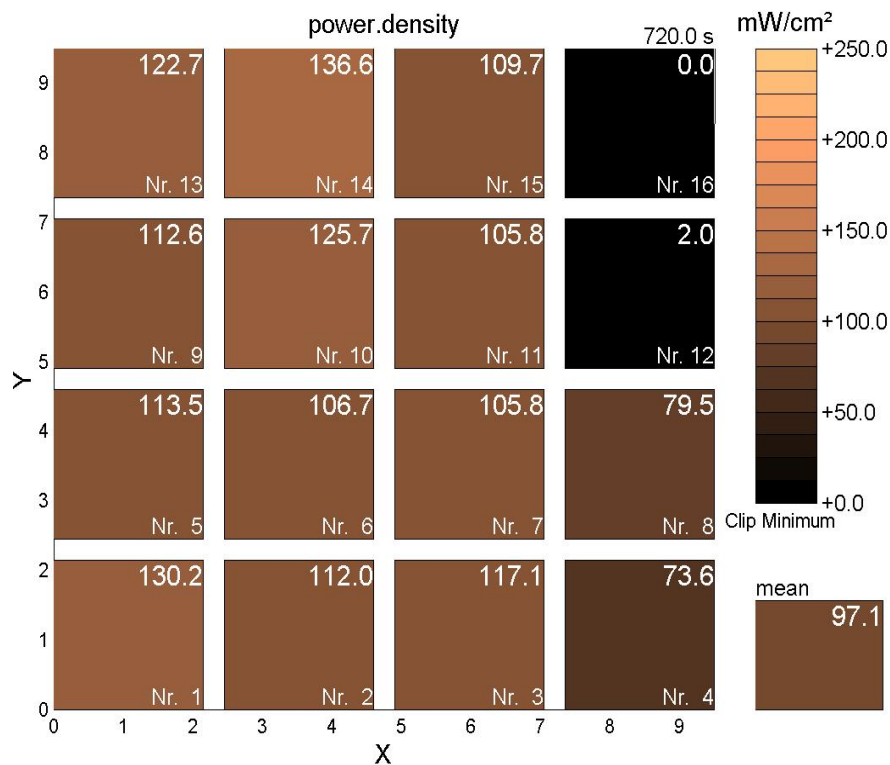
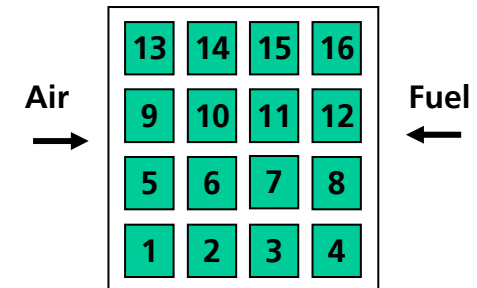
- All cell types applicable
- Improved contacting
- More reliable sealing
- Impedance measurements
- Reliable temperature measurement



Results – flow design

Plasma sprayed cell with LSCF (NT107B02)

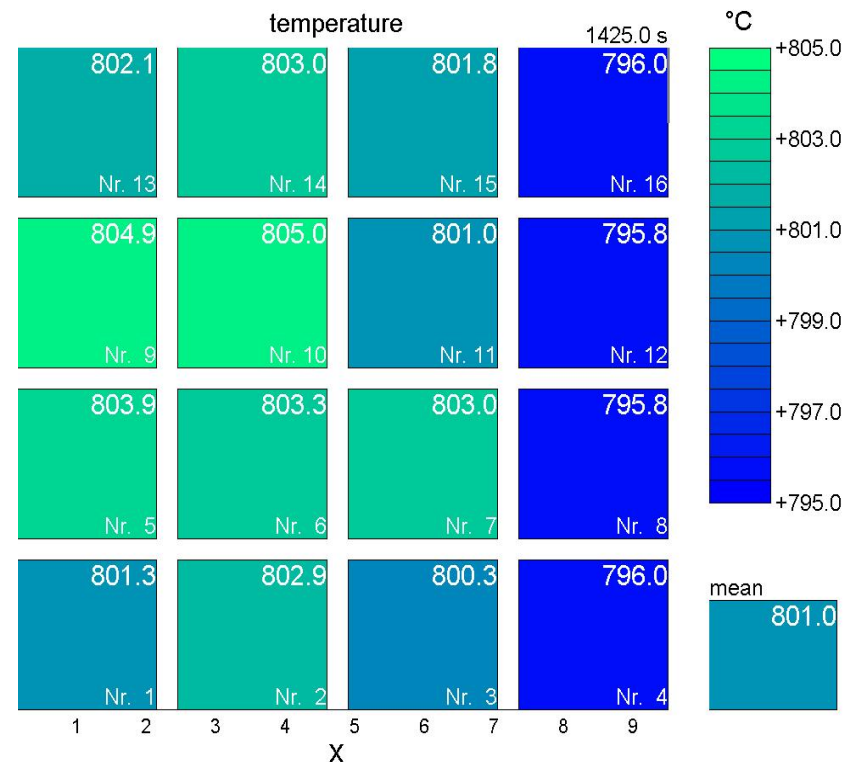
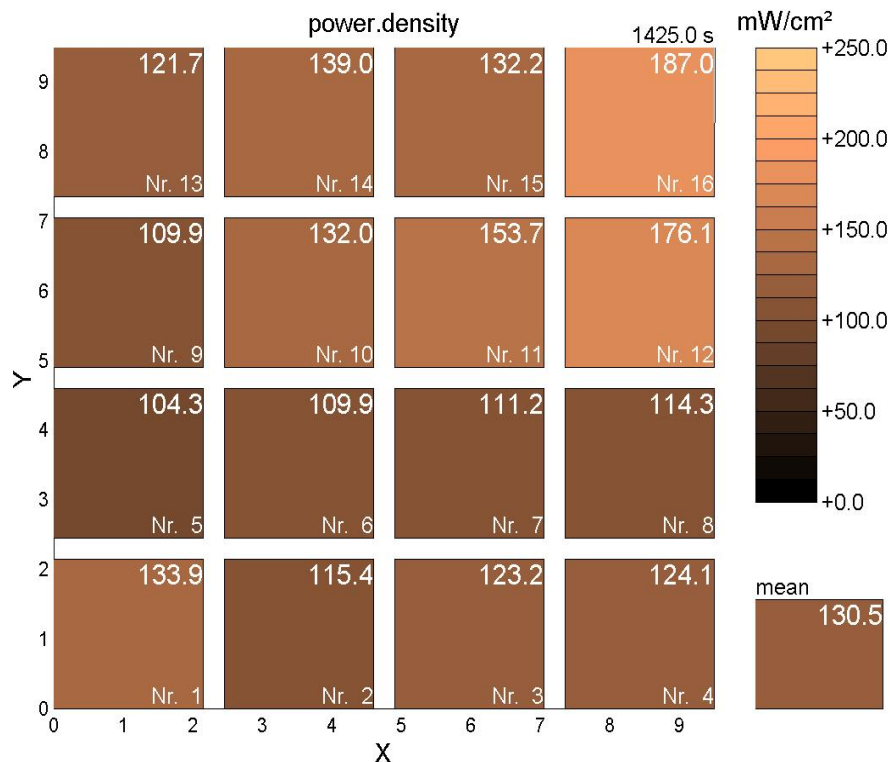
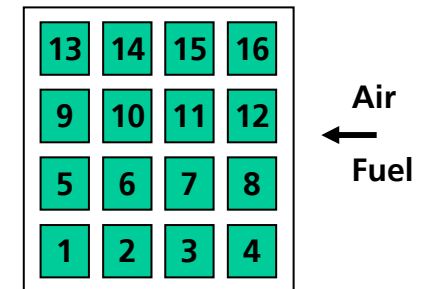
- P und T distribution at standard gas flow rates:
12,5/12,5//80 smlpm/cm² H₂/N₂//Air, 800°C, 0,6V,
after 189h, counter flow



Results – flow design

Plasma sprayed cell with LSCF (NT107B02)

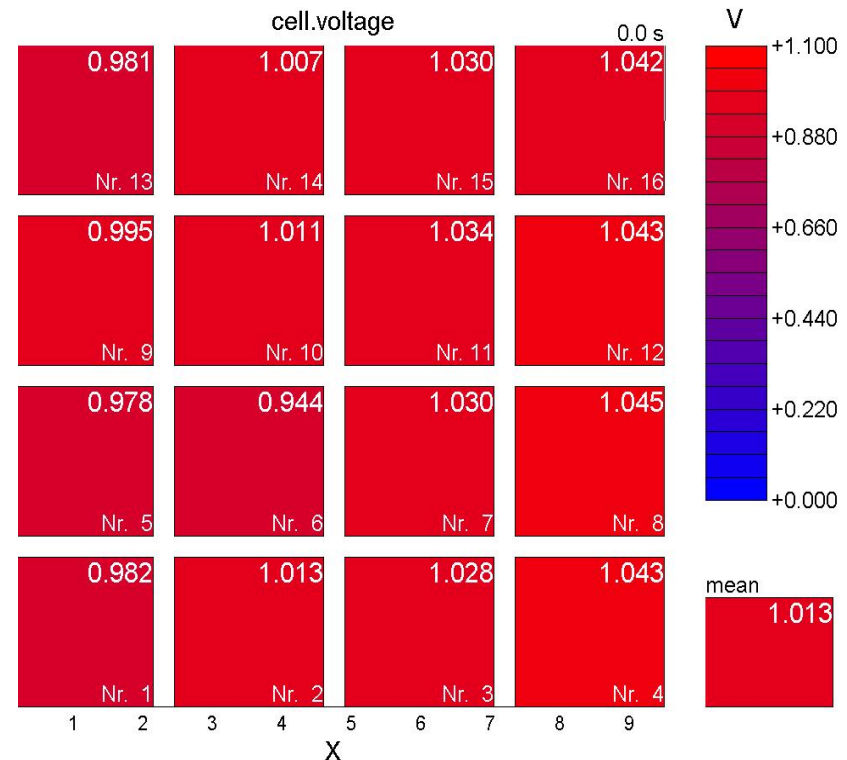
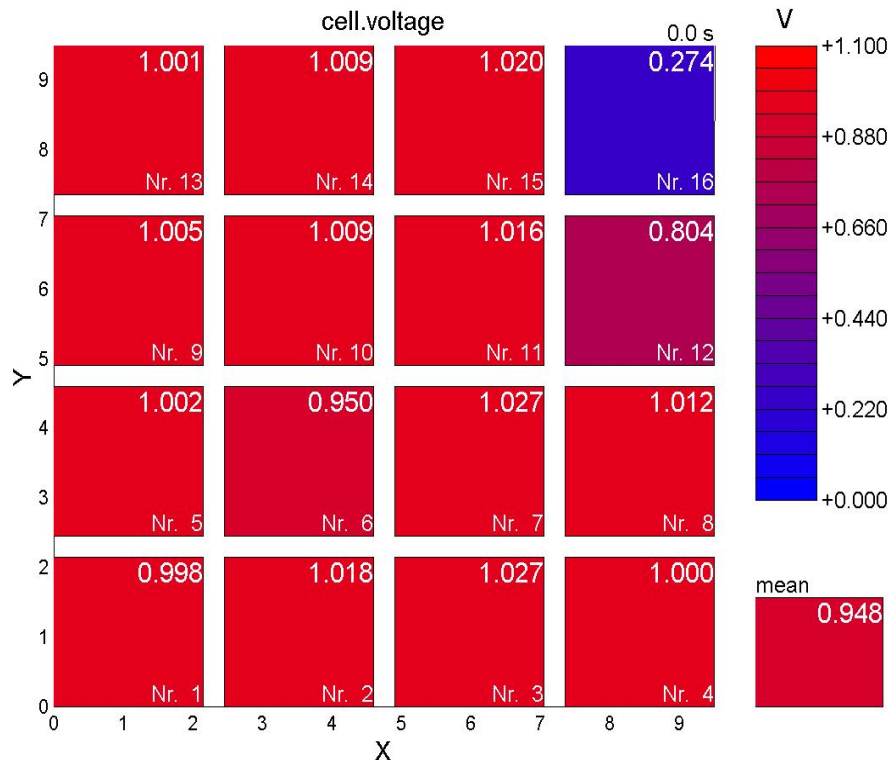
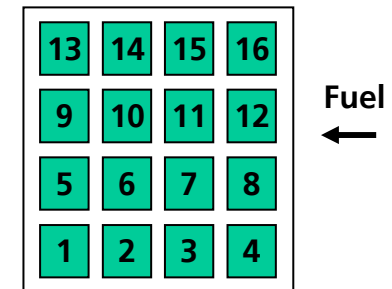
- P und T distribution at standard gas flow rates:
12,5/12,5//80 smlpm/cm² H₂/N₂//Air, 800°C, 0,6V,
after 193h, co flow

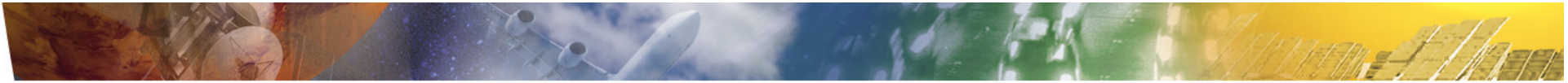


Results – effect of leakage on voltage

Plasma sprayed cell with LSCF (NT107B02)

- V distribution at **OCV** with co and counter gas flow:
 L: 12,5/12,5//80 smlpm/cm² H₂/N₂//Air, 800°C, **counter**
 R: 12,5/12,5//80 smlpm/cm² H₂/N₂//Air, 800°C, **co**

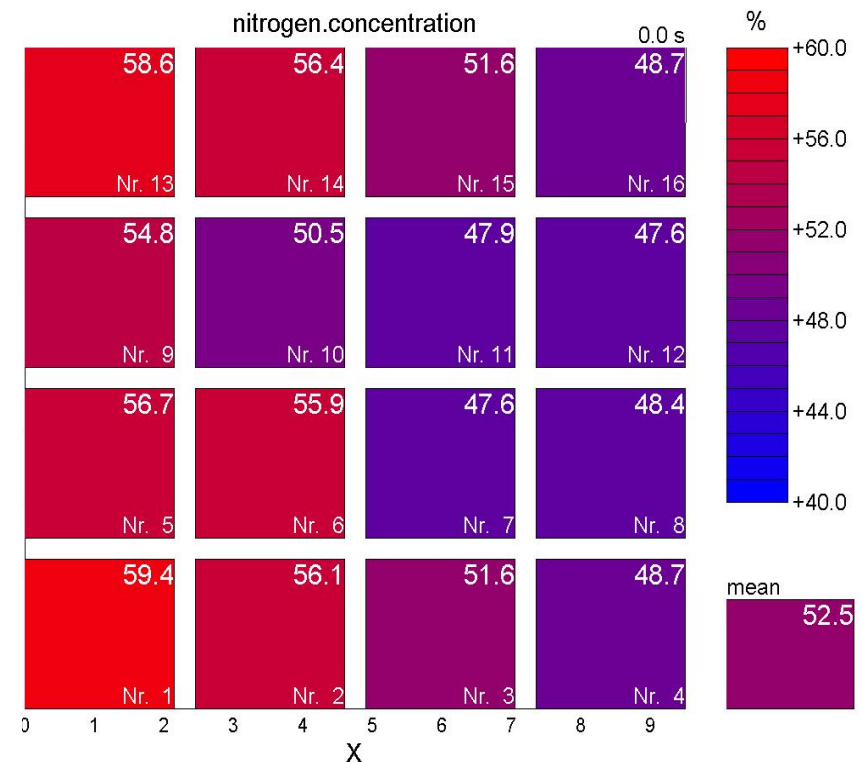
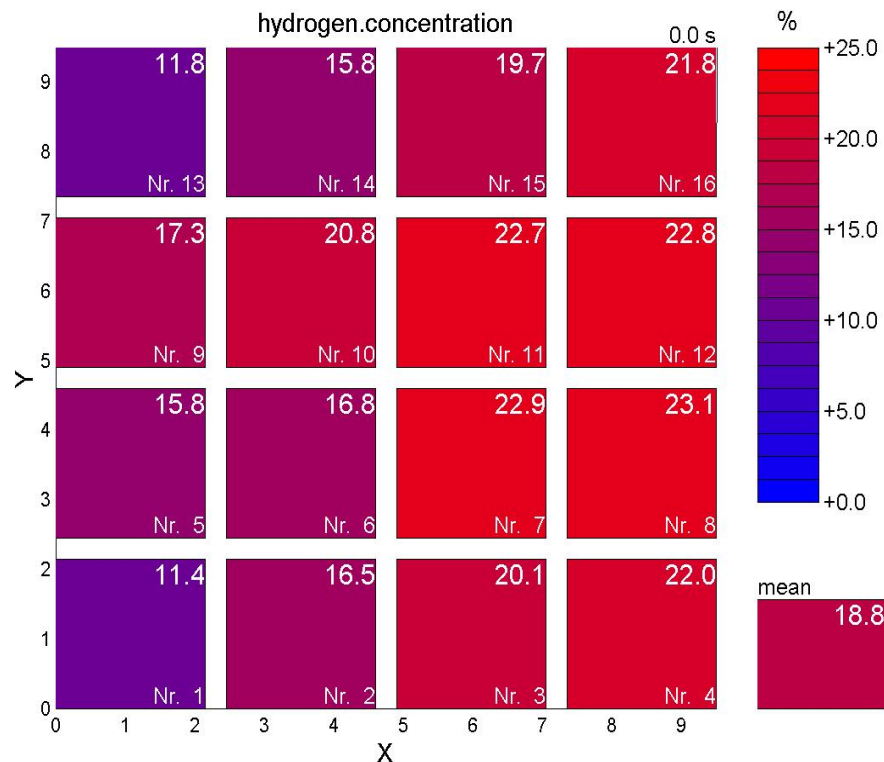
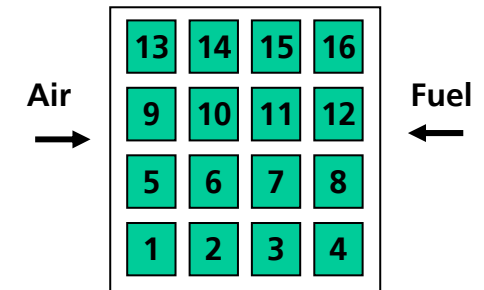




Results – effect of leakage on the concentrations

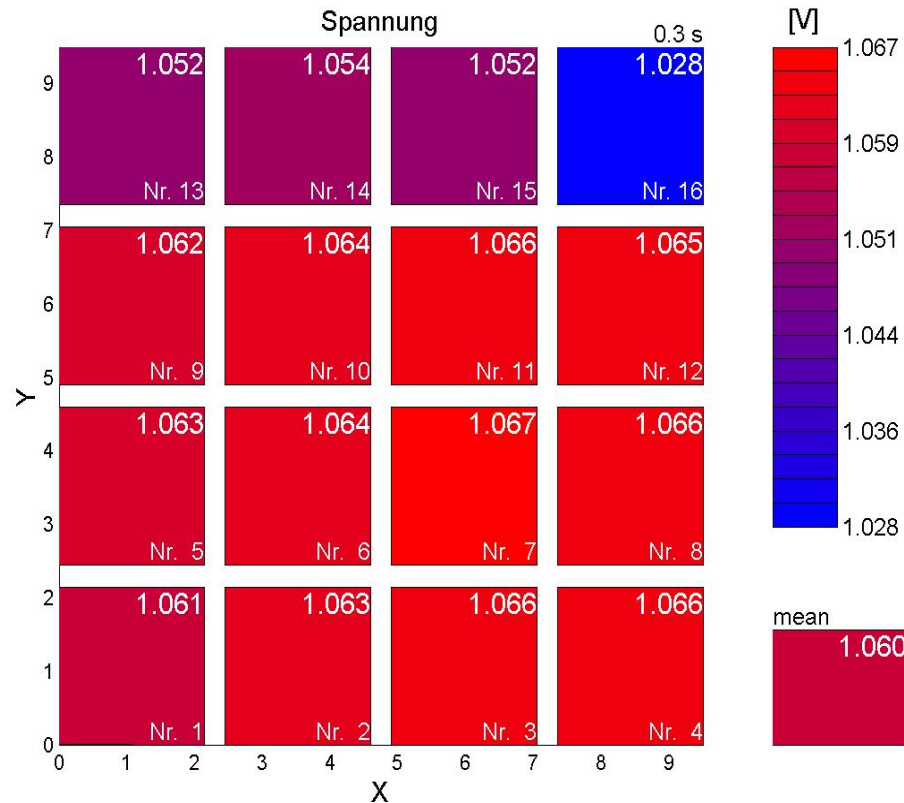
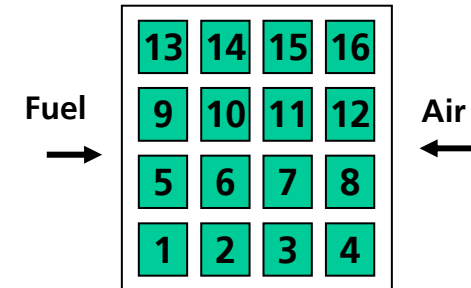
Leaky pre-test cell (Te142)

- Gas concentration distribution at 800°C:
Gas flow rates: 25%H₂, 25%CO, 50%N₂
6,8/6,8/13,5//68 smlpm/cm² H₂/CO/N₂//Air



Determination of Steam Content at Operation with Reformate

- Voltage distribution at **standard flow rate**:
- 1.79 A/cm² current density equivalent, 50% H₂, 50% N₂ + 3% H₂O, 0,08 SlpM/cm² air

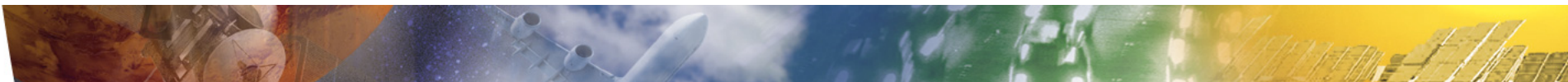


Nernst equation:

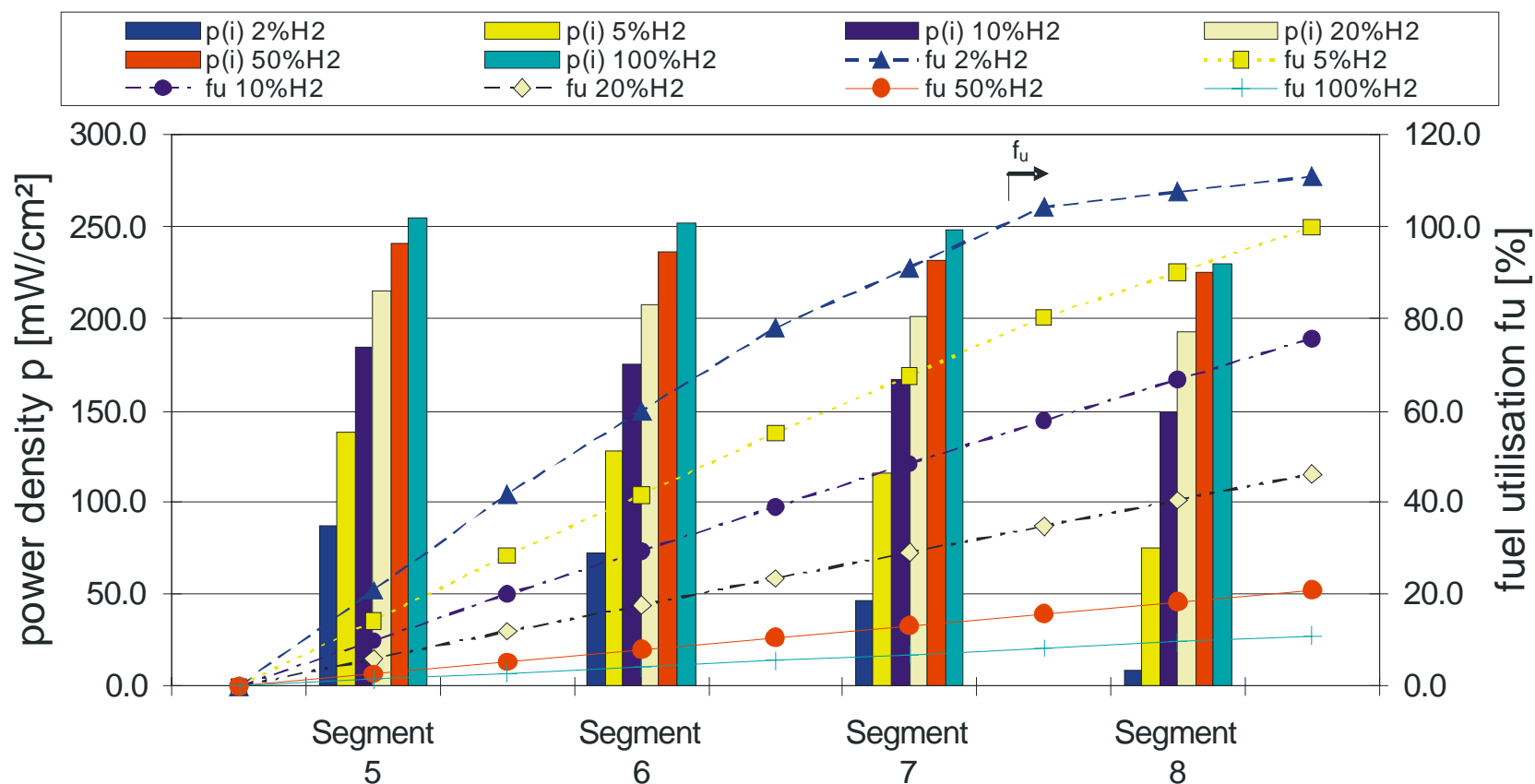
$$U_{rev} = U_{rev}^0 - \frac{RT}{zF} \ln \left(\frac{p_{H_2O}}{\sqrt{p_{O_2} p_{H_2}}} \right)$$

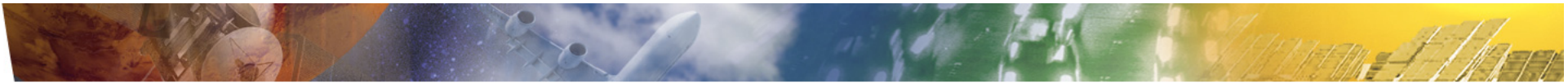
Chemically produced water:

S4: 0,61%, S8: 0,72%,
S12: 0,78%, S16: 3,30%

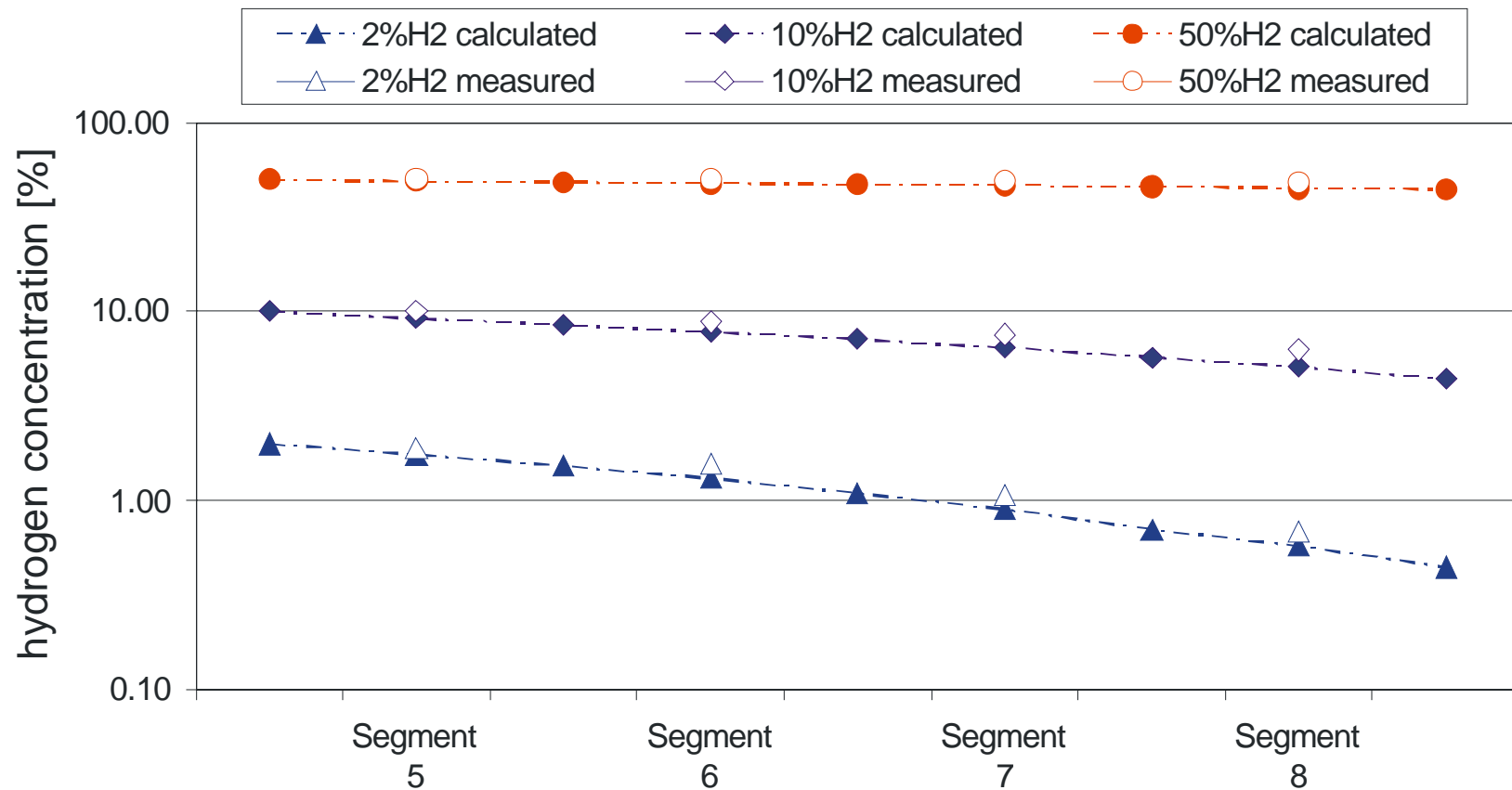


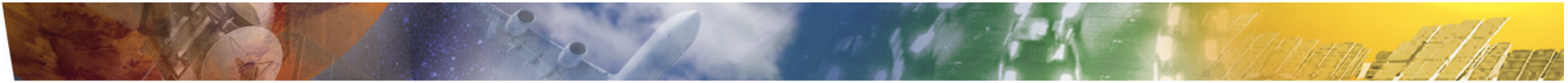
Locally Resolved Power Density Distribution and Fuel Utilisation in Dependence of H₂ Concentrations





Comparison of Calculated and Measured H₂ Concentration by Gas Chromatography For a Segment Row





Conclusion

- World wide increasing interest on metal supported SOFC cells, particularly for mobile application
- Long-term stability of the metallic support is an important requirement for metal supported cell technology
- Improvement of long-term cell operation by applying plasma sprayed diffusion barrier layer
- An adequate cell and stack design for plasma sprayed cells in cassette configuration has been developed
- The development of the metal supported SOFC concept has a high potential for SOFC application in dynamic operation with multiple thermal and redox cycles
- Spatially-resolved measuring techniques are important analytical tools to optimise cell operation